FILE 'HOME' ENTERED AT 10:59:48 ON 14 OCT 2003

=> file reg

COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 0.21 0.21

FULL ESTIMATED COST

FILE 'REGISTRY' ENTERED AT 11:00:09 ON 14 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 American Chemical Society (ACS)

Property values tagged with IC are from the ZIC/VINITI data file provided by InfoChem.

STRUCTURE FILE UPDATES: 13 OCT 2003 HIGHEST RN 603932-08-7 DICTIONARY FILE UPDATES: 13 OCT 2003 HIGHEST RN 603932-08-7

TSCA INFORMATION NOW CURRENT THROUGH JULY 14, 2003

Please note that search-term pricing does apply when conducting SmartSELECT searches.

Crossover limits have been increased. See HELP CROSSOVER for details.

Experimental and calculated property data are now available. See HELP PROPERTIES for more information. See STNote 27, Searching Properties in the CAS Registry File, for complete details: http://www.cas.org/ONLINE/STN/STNOTES/stnotes27.pdf

=> s 14-22 cr/mac

205313 14-22/MAC

276614 CR/MAC

L1 73627 14-22 CR/MAC

(14-22/MAC (P) CR/MAC)

=> s 4-10 pt/mac

329018 4-10/MAC

13042 PT/MAC

L2 2089 4-10 PT/MAC

(4-10/MAC (P) PT/MAC)

=> s 1-5 ta/mac

514524 1-5/MAC

22063 TA/MAC

L3 7960 1-5 TA/MAC

(1-5/MAC (P) TA/MAC)

=> s 63-81 co/mac

212438 63-81/MAC

109921 CO/MAC

L4 10483 63-81 CO/MAC

(63-81/MAC (P) CO/MAC)

=> s 11 and 12 and 13 and 14

L5 39 L1 AND L2 AND L3 AND L4

=> s 1-5 nb/mac

514524 1-5/MAC

69004 NB/MAC

L6 18754 1-5 NB/MAC

(1-5/MAC (P) NB/MAC)

=> s 15 and 16 9 L5 AND L6

=> file caplus COST IN U.S. DOLLARS

SINCE FILE TOTAL SESSION ENTRY 22.91 22.70

FULL ESTIMATED COST

FILE 'CAPLUS' ENTERED AT 11:02:24 ON 14 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

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FILE COVERS 1907 - 14 Oct 2003 VOL 139 ISS 16 FILE LAST UPDATED: 13 Oct 2003 (20031013/ED)

This file contains CAS Registry Numbers for easy and accurate substance identification.

=> s 15

24 L5 L8

=> s 17

L9 5 L7

=> d 1-

YOU HAVE REQUESTED DATA FROM 5 ANSWERS - CONTINUE? Y/(N):y

- ANSWER 1 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN 1.9
- 2002:770073 CAPLUS ΔN
- DΝ 137:287959
- Magnetic recording medium with dual magnetic layers and high in-plane TΤ coercivity
- Chen, Qixu David; Huang, Lin; Leu, Charles; Ranjan, Rajiv Yadav TN
- Seagate Technology, Inc., USA PA
- U.S., 12 pp. SO

CODEN: USXXAM

DT Patent

English LA

FAN. CNT 1

FAN.CNI I						
PATENT NO.		KIND	DATE	APPLICATION NO.	DATE	
		-				
PI US 64	161750	B1	20021008	US 1999-406816	19990928	
US 20	03039863	A1	20030227	US 2002-252708	20020924	
PRAI US 19	998-102573P	P	19980930			
US 19	999-406816	A3	19990928			

THERE ARE 16 CITED REFERENCES AVAILABLE FOR THIS RECORD RE.CNT 16 ALL CITATIONS AVAILABLE IN THE RE FORMAT

L9 ANSWER 2 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN

AN 2002:630296 CAPLUS

```
DN
    137:149161
    Magnetic recording disk for hard disk drive.
ΤI
    Lai, Tai-Huang; Luo, Yu-Yun; Tung, Jiun-Yan; Liang, Wei-Jeng; Liang,
IN
    Hung-Huei
    Trace Storage Technology Corp., Taiwan
PA
SO
    Taiwan, 19 pp.
    CODEN: TWXXA5
DT
    Patent
LA
    Chinese
FAN.CNT 1
               KIND DATE
                                       APPLICATION NO. DATE
    PATENT NO.
                  ----
                                       ______
    TW 392150 B
                        20000601
                                       TW 1998-87110336 19980626
PΤ
PRAI TW 1998-87110336
                        19980626
    ANSWER 3 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
    2000:716092 CAPLUS
AN
DN
    133:275473
    Fabrication of magnetic recording medium and magnetic recording disk
ΤI
    Okuyama, Chiaki; Sato, Kenji; Yoshida, Yuki; Okamoto, Iwao
IN
PA
    Fujitsu Ltd., Japan
SO
    U.S., 20 pp.
    CODEN: USXXAM
DT
    Patent
LA
    English
FAN.CNT 1
                  KIND DATE
                                      APPLICATION NO. DATE
    PATENT NO.
                                       -----
    ______
    US 6129981 A
                        20001010
                                       US 1998-187082 19981106
PΤ
PRAI JP 1998-39259
                   Α
                        19980220
           THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT 9
            ALL CITATIONS AVAILABLE IN THE RE FORMAT
    ANSWER 4 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
    2000:274654 CAPLUS
AN
    132:302339
DN
    Magnetic recording media and magnetic disk apparatus
TI
    Sato, Kenji; Yoshida, Yuki; Okuyama, Tomoaki
ΙN
    Fujitsu Ltd., Japan
PΑ
    Jpn. Kokai Tokkyo Koho, 16 pp.
SO
    CODEN: JKXXAF
DТ
    Patent
LA
    Japanese
FAN.CNT 1
                  KIND DATE
                                      APPLICATION NO. DATE
    PATENT NO.
    -----
                                       _____
                    A2 20000428
    JP 2000123345
                                       JP 1998-298665 19981020
PΙ
PRAI JP 1998-298665
                         19981020
    ANSWER 5 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
    1993:522953 CAPLUS
AN
DN
    119:122953
    Cobalt-chromium-platinum alloys for sputtering targets in application of
ΤI
    magnetic recording films
    Kinoshita, Makoto; Ishii, Toshinori; Tamura, Jun; Kishida, Kunio
IN
    Mitsubishi Materials Corp, Japan
PA
    Jpn. Kokai Tokkyo Koho, 10 pp.
SO
    CODEN: JKXXAF
DT
    Patent
    Japanese
LA
FAN.CNT 1
                                      APPLICATION NO. DATE
    PATENT NO.
                   KIND DATE
                   ----
```

```
19930406
     JP 05086456
                      A2
                                           JP 1991-76575
                                                            19910409
PΙ
                           19910409
PRAI JP 1991-76575
=> d 1- all
YOU HAVE REQUESTED DATA FROM 5 ANSWERS - CONTINUE? Y/(N):y
     ANSWER 1 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
     2002:770073 CAPLUS
AN
     137:287959
DN
     Magnetic recording medium with dual magnetic layers and high in-plane
ΤI
     Chen, Qixu David; Huang, Lin; Leu, Charles; Ranjan, Rajiv Yadav
IN
PA
     Seagate Technology, Inc., USA
SO
     U.S., 12 pp.
     CODEN: USXXAM
DT
     Patent
LA
     English
     ICM G11B005-66
TC
     ICS G11B005-70
NCL
     428694000TM
     77-8 (Magnetic Phenomena)
CC
FAN.CNT 1
     PATENT NO.
                      KIND DATE
                                          APPLICATION NO. DATE
                      ----
                                           _____
                                                           _____
PI < US 6461750
                       В1
                            20021008
                                           US 1999-406816
                                                            19990928
     US 2003039863
                       A1
                            20030227
                                           US 2002-252708
                                                            20020924
PRAI US 1998-102573P
                      Р
                            19980930
                      A3
                            19990928
     US 1999-406816
AB
     A magnetic recording media is formed with high in-plane coercivity
     employing dual magnetic layers. The 1st magnetic layer is sputter
     deposited in a chamber employing a shield such that the min. incident
     angle of impinging atoms is relatively large, e.g., .gtorsim.26.degree..
     Embodiments of the present invention comprise depositing a NiAl seed
     layer, a Cr or Cr alloy underlayer and a 1st CoCrTa magnetic layer at a
     thickness .ltorsim.50 .ANG. for inducing the preferred (10.0) crystallog.
     orientation in the subsequently deposited 2nd magnetic layer, e.g.,
    COCrPtTa or CoCrPtTaNb having a high Cr content of .apprx.16 to .apprx.21
     cobalt chromium platinum tantalum dual layer recording medium coercivity
ST
     Coercive force (magnetic)
IT
     Magnetic multilayers
     Magnetic recording materials
     Sputtering
        (cobalt-chromium alloy magnetic recording medium with dual magnetic
        layers and high in-plane coercivity)
IT
     7440-47-3P, Chromium, uses
                                 12635-27-7P
                                                77325-66-7P
                                                              137850-97-6P
                   467233-21-2P 467233-22-3P
     238087-04-2P
     RL: DEV (Device component use); PNU (Preparation, unclassified); TEM
     (Technical or engineered material use); PREP (Preparation); USES (Uses)
        (cobalt-chromium alloy magnetic recording medium with dual magnetic
        layers and high in-plane coercivity)
RE.CNT
       16
              THERE ARE 16 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE
(1) Akimoto; IEEE Transactions on Magnetics 1998, V34(4), P1
(2) Alex; US 5616218 A 1997 CAPLUS
(3) Bertero; US 6150015 A 2000 CAPLUS
(4) Bian; US 6077586 A 2000 CAPLUS
(5) Bian; US 6143388 A 2000 CAPLUS
(6) Chen; US 5763071 A 1998 CAPLUS
```

(7) Futamoto; US 6251532 B1 2001 CAPLUS

(10) Lee; IEEE Transactions on Magnetics 1994, V30(6), P3951 CAPLUS

(8) Lee; US 5693426 A 1997 CAPLUS (9) Lee; US 5800931 A 1998 CAPLUS

```
(11) Ohkubo; US 5851656 A 1998 CAPLUS
(12) Peng; IEEE Transactions on Magnetics 1995, V31(6), P2821 CAPLUS
(13) Ross; Journal of Applied Physics: Proceedings of the 41st Annual Conference
   on Magnetism and Magnetic Materials, Part 2A 1997, V81(8) CAPLUS
(14) Song; US 6150016 A 2000 CAPLUS
(15) Zhang; US 5772857 A 1998 CAPLUS
(16) Zhang; US 6077603 A 2000 CAPLUS
     ANSWER 2 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
    2002:630296 CAPLUS
AN
    137:149161
DN
    Magnetic recording disk for hard disk drive.
ΤI
    Lai, Tai-Huang; Luo, Yu-Yun; Tung, Jiun-Yan; Liang, Wei-Jeng; Liang,
IN
    Hung-Huei
     Trace Storage Technology Corp., Taiwan
PA
SO
     Taiwan, 19 pp.
     CODEN: TWXXA5
DT
     Patent
    Chinese
T,A
IC
     ICM G11B005-62
     77-8 (Magnetic Phenomena)
CC
     Section cross-reference(s): 57
FAN.CNT 1
     PATENT NO.
                    KIND DATE
                                         APPLICATION NO. DATE
                                          -----
     -----
                                          TW 1998-87110336 19980626
     TW 392150
                      В
                           20000601
PΙ
PRAI TW 1998-87110336
                          19980626
     The present invention relates to high-coercivity magnetic recording disk
     used in hard disk drive. The magnetic recording disk comprises a
     nonmagnetic substrate, a fine grain-structured Ni-Al alloy seed layer
     (thickness 200-1000 .ANG.) sputtered on the substrate, a Cr-V alloy
     intermediate layer (thickness 50-1000 .ANG..) sputtered on the seed layer,
     a Co-Cr-Pt-Ta-Nb alloy magnetic layer (thickness 100-400 .ANG.) sputtered
     on the intermediate layer, and a carbon protective layer sputtered on the
     magnetic layer. The nonmagnetic substrate may be made from glass,
     ceramic, glass ceramic, Al alloy, etc. The Co-Cr-Pt-Ta-Nb alloy magnetic
     layer-contg. magnetic recording disk has coercivity (Hc) higher than 4000
     magnetic recording disk hard disk drive; coercivity magnetic recording
ST
     disk hard disk drive; hard magnetic disk coercivity
IT
    Heating
        (IR; magnetic recording disk for hard disk drive)
IT
     Lubricating oils
        (coating; magnetic recording disk for hard disk drive)
     Coating process
ΙT
        (electroless; magnetic recording disk for hard disk drive)
     Magnetic disks
IT
        (hard; magnetic recording disk for hard disk drive)
ΙT
     Coercive force (magnetic)
     Magnetic disks
     Sputtering
        (magnetic recording disk for hard disk drive)
IT
     Ceramics
     Glass ceramics
        (substrate; magnetic recording disk for hard disk drive)
IT
     Glass, uses
     RL: DEV (Device component use); USES (Uses)
        (substrate; magnetic recording disk for hard disk drive)
IT
     Aluminum alloy, base
     RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses)
        (substrate; magnetic recording disk for hard disk drive)
     11104-08-8, Nickel phosphide 12035-46-0, Nickel phosphide (NiP)
IT
     RL: TEM (Technical or engineered material use); USES (Uses)
        (coating, electroless plated; magnetic recording disk for hard disk
```

```
drive)
     37283-60-6, Chromium alloy, Cr, V
IT
     RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses)
        (intermediate layer; magnetic recording disk for hard disk drive)
     238087-04-2, Cobalt alloy, Co, Cr, Nb, Pt, Ta 297178-07-5
TT
     444725-28-4
     RL: DEV (Device component use); PRP (Properties); USES (Uses)
        (magnetic recording disk for hard disk drive)
     7440-44-0, Carbon, uses
IT
     RL: DEV (Device component use); TEM (Technical or engineered material
     use); USES (Uses)
        (protective coating; magnetic recording disk for hard disk drive)
     12635-29-9, Nickel alloy, Ni, Al
IT
     RL: DEV (Device component use); USES (Uses)
        (seed layer; magnetic recording disk for hard disk drive)
     11145-10-1, Aluminum alloy, Al, Mg
IT
     RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses)
        (substrate; magnetic recording disk for hard disk drive)
     ANSWER 3 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
     2000:716092 CAPLUS
AN
     133:275473
DN
     Fabrication of magnetic recording medium and magnetic recording disk
TI
     Okuyama, Chiaki; Sato, Kenji; Yoshida, Yuki; Okamoto, Iwao
IN
     Fujitsu Ltd., Japan
PA
     U.S., 20 pp.
so
     CODEN: USXXAM
DT
     Patent
LA
     English
IC
     ICM G11B005-66
     428332000
NCL
     77-8 (Magnetic Phenomena)
CC
     Section cross-reference(s): 56
FAN.CNT 1
     PATENT NO.
                      KIND DATE
                                           APPLICATION NO. DATE
                            _____
     ----
                                           _____
                      ----
                                           US 1998-187082
                                                            19981106
    ÚS 612<u>9981</u>
                       Α
                            20001010
PRAI JP 1998-39259
                       Α
                            19980220
     A magnetic recording medium and a magnetic disk device fabrication is
     presented. The magnetic recording medium comprising a nonmagnetic
     substrate having applied thereon, through a chromium-based underlayer, at
     least one magnetic recording layer consisting of cobalt as a principal
     component, 14 to 23 at % of chromium, 1 to 20 at % of platinum as well as
     tungsten and carbon. The magnetic recording medium exhibits reduced
     noise, an improved resoln. of the reproducing waveforms and an increased
     S/N ratio.
     magnetic recording medium disk device fabrication
st
IT
     Magnets
        (circuits; in fabrication of magnetic recording medium and magnetic
        recording disk device)
ΙT
     Magnetic disks
        (fabrication of)
     Magnetic recording heads
IT
     Magnetic recording materials
        (fabrication of magnetic recording medium and magnetic recording disk
        device)
ΙT
     Controlled atmospheres
     Magnetic materials
     Sputtering
        (in fabrication of magnetic recording medium and magnetic recording
        disk device)
IT
     Electronic device fabrication
        (of magnetic recording medium and magnetic recording disk device)
```

```
IT
     7429-90-5, Aluminum, processes
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (NiP coated disk substrate; in fabrication of magnetic recording medium
        and magnetic recording disk device)
IT
     7440-37-1, Argon, processes
     RL: NUU (Other use, unclassified); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (atm.; in fabrication of magnetic recording medium and magnetic
        recording disk device)
     12035-46-0, Nickel phosphide (NiP)
IT
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (coated aluminum; in fabrication of magnetic recording medium and
        magnetic recording disk device)
     7440-47-3, Chromium, processes
                                      129617-87-4, Chromium 13, cobalt 75,
TΤ
     platinum 12
                   297178-05-3, Carbon 1, chromium 17, cobalt 73, platinum 5,
     tungsten 4
                  297178-06-4, Carbon 1, chromium 0-23, cobalt 67-90, platinum
     5, tungsten 4 297178-07-5, Chromium 17, cobalt 74, niobium 2,
    platinum 5, tantalum 2 | 297178-08-6, Chromium 0-13, cobalt 78-91, niobium
     2, platinum 5, tantalum 2 297178-09-7, Chromium 13-21, cobalt
     70-78, niobium 2, platinum 5, tantalum 2 297178-10-0, Carbon 1-6,
     chromium 13-21, cobalt 52-79, platinum 1-20, tungsten 1-6
     297178-11-1, Chromium 13-21, cobalt 72-79, niobium 1-6, platinum
     1-20, tantalum 1-6
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (in fabrication of magnetic recording medium and magnetic recording
        disk device)
IT
     112336-81-9
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (non-magnetic layer; in fabrication of magnetic recording medium and
        magnetic recording disk device)
              THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT
RE
(1) Anon; JP 60228637 1985 CAPLUS
(2) Anon; JP 63148411 1988
(3) Anon; JP 750008 1995
(4) Anon; JP 750009 1995
(5) Chen; US 5763071 1998 CAPLUS
(6) Inoue; US 4814238 1989
(7) Ohkubo; US 5851656 1998 CAPLUS
(8) Yamaguchi; US 5552217 1996
(9) Zhang; US 5952097 1999 CAPLUS
     ANSWER 4 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
     2000:274654 CAPLUS
AN
DN
     132:302339
     Magnetic recording media and magnetic disk apparatus
TI
     Sato, Kenji; Yoshida, Yuki; Okuyama, Tomoaki
IN
     Fujitsu Ltd., Japan
PA
     Jpn. Kokai Tokkyo Koho, 16 pp.
so
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
     ICM G11B005-66
IC
     ICS H01F010-26; H01F010-30
CC
     77-8 (Magnetic Phenomena)
FAN.CNT 1
                                           APPLICATION NO. DATE
     PATENT NO.
                      KIND DATE
                     - - <del>-</del> -
                           -----
     JP 2000123345
                       A2
                            20000428
                                           JP 1998-298665 19981020
PΙ
PRAI JP 1998-298665
                            19981020
```

```
nonmagnetic substrates, and antiferromagnetic base layers are formed in
     contact with the recording layers.
     magnetic recording media disk app; ferromagnetic elec magnetic recording
ST
     media
     Ferromagnetic films
IT
     Magnetic disks
     Magnetic recording materials
        (magnetic recording media and magnetic disk app.)
IΤ
     69020-63-9
                264870-62-4 264870-63-5
     RL: DEV (Device component use); USES (Uses)
        (magnetic recording media and magnetic disk app. contg.
        antiferromagnetic materials)
IT
     264870-64-6
     RL: DEV (Device component use); USES (Uses)
        (magnetic recording media and magnetic disk app. contg. ferromagnetic
        materials)
    ANSWER 5 OF 5 CAPLUS COPYRIGHT 2003 ACS on STN
L9
AN
     1993:522953 CAPLUS
DN
     119:122953
     Cobalt-chromium-platinum alloys for sputtering targets in application of
TI
     magnetic recording films
     Kinoshita, Makoto; Ishii, Toshinori; Tamura, Jun; Kishida, Kunio
ΙN
PA
     Mitsubishi Materials Corp, Japan
     Jpn. Kokai Tokkyo Koho, 10 pp.
SO
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
IC
     ICM C23C014-14
     ICS C23C014-34
     56-4 (Nonferrous Metals and Alloys)
CC
     Section cross-reference(s): 77
FAN.CNT 1
     PATENT NO.
                    KIND DATE
                                          APPLICATION NO. DATE
     ______
PΙ
    JP 05086456
                    A2 19930406
                                          JP 1991-76575
                                                          19910409
                          19910409
PRAI JP 1991-76575
     The targets useful for coating with high coercive force in magnetic
AB
     recording app. are manufd. from the Co alloys contg. Cr 5-20, Pt 10-55%,
     and optionally Ni, Ta, Pd, and/or Nb 0.1-20% each, Zr, Ti, Hf, Al, Si, Mo,
     W, V, and/or Cu 0.01-7% each, and/or Mg, Ca, La, Ce, and/or Nd 0.005-3%
ST
     sputtering target cobalt alloy; cobalt chromium platinum alloy sputtering;
     magnetic recording cobalt alloy
IT
     Recording materials
        (cobalt-chromium-platinum alloys, sputtered coating with)
IT
     Coercive force, magnetic
        (of cobalt-chromium-platinum alloys, in magnetic recording)
IT
     Sputtering
        (targets, cobalt-chromium-platinum alloys, in magnetic recording)
TΤ
                 148942-10-3 148942-11-4 148942-12-5 148942-13-6
     148942-09-0
                 148942-15-8 148942-16-9
                                              148942-17-0
                                                            148942-18-1
     148942-14-7
                 148942-20-5 148942-21-6
     148942-19-2
                                              148942-22-7
                                                            148942-23-8
                 148942-25-0. 148942-26-1
     148942-24-9
                                              148942-27-2
                                                            148942-28-3
     148942-29-4 148942-30-7 148994-33-6 148994-34-7
     148994-35-8 148994-36-9 148994-37-0 148994-38-1
     149531-05-5
     RL: USES (Uses)
        (sputtering target, for magnetic recording app.)
```

YOU HAVE REQUESTED DATA FROM 24 ANSWERS - CONTINUE? Y/(N):y

Magnetic recording layers from ferromagnetic substances are formed on

AB

=> d l8 1- all

```
ANSWER 1 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
    2003:633123 CAPLUS
AN
DN
     139:158818
    Design of a magnetic recording medium with improved exchange coupling
TI
    Bertero, Gerardo; Malhotra, Sudhir; Wachenschwanz, David; Shan,
IN
     Zhengsheng; Stafford, Donald
PA
     Komag, Inc., USA
    U.S. Pat. Appl. Publ., 19 pp.
SO
     CODEN: USXXCO
DT
    Patent
    English
LA
     ICM B32B009-00
IC
    428692000; 428694000MT; 428694000RE
NCL
     77-8 (Magnetic Phenomena)
     Section cross-reference(s): 55, 56
FAN.CNT 1
                                          APPLICATION NO. DATE
     PATENT NO.
                     KIND DATE
                                          -----
     _____
                                          US 2002-75123
                                                           20020212
PΙ
    US 2003152805
                    A1
                           20030814
                                          DE 2003-10304865 20030206
    DE 10304865
                      A1
                           20030821
                                          JP 2003-31989 20030210
     JP 2003263715
                      A2
                           20030919
                    Α
PRAI US 2002-75123
                           20020212
     The invention relates to the design of a magnetic recording medium with
     improved exchange coupling. The recording medium consists of (i) a
     substrate; (ii) a lower magnetic layer structure formed over the
     substrate, where the lower magnetic layer structure exhibits an Ms of >250
     emu/cm3; (iii) an intermediate layer consisting of Ru; and (iv) an upper
     magnetic layer structure formed over the intermediate layer, where the
     upper magnetic layer structure is antiferromagnetically coupled to the
     lower magnetic layer structure.
     magnetic recording medium improved exchange coupling
ST
     Antiferromagnetic exchange
IT
     Magnetic films
     Magnetic recording materials
        (design of a magnetic recording medium with improved exchange coupling)
IT
     Boron alloy, nonbase
     Carbon alloy, nonbase
     Chromium alloy, nonbase
     Cobalt alloy, nonbase
     Copper alloy, nonbase
     Iridium alloy, nonbase
     Molybdenum alloy, nonbase
     Niobium alloy, nonbase
     Palladium alloy, nonbase
     Platinum alloy, nonbase
     Ruthenium alloy, nonbase
     Silicon alloy, nonbase
     Tantalum alloy, nonbase
     Tantalum alloy, nonbase
     Tungsten alloy, nonbase
     Vanadium alloy, nonbase
     Yttrium alloy, nonbase
     RL: TEM (Technical or engineered material use); USES (Uses)
        (design of a magnetic recording medium with improved exchange coupling)
     7440-18-8, Ruthenium, uses 11068-82-9, Permalloy
ΙT
                                                        11101-28-3
     12606-95-0, Sendust 12649-48-8
                                       12781-95-2
                                                    39284-68-9
     77088-24-5 91867-19-5
                             93844-66-7
                                           149344-82-1 570383-69-6,
     Boron 0-10, chromium 5-20, cobalt 54-95, platinum 0-10, tantalum 0-6
     (atomic) 570383-71-0, Boron 0-20, chromium 10-30, cobalt 30-82, platinum
     8-20 (atomic)
     RL: TEM (Technical or engineered material use); USES (Uses)
        (design of a magnetic recording medium with improved exchange coupling)
```

L8

- L8 ANSWER 2 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN .
- AN 2002:927036 CAPLUS
- DN 138:10785
- TI Perpendicular magnetic recording medium, its preparation, and magnetic recording/reading apparatus employing same
- IN Shimizu, Kenji; Sakawaki, Akira; Sakai, Hiroshi; Nakamura, Futoshi; Hikosaka, Kazushi
- PA Showa Denko K. K., Japan; Toshiba Corp.
- SO Jpn. Kokai Tokkyo Koho, 14 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- IC ICM G11B005-667
 - ICS G11B005-65; G11B005-66; G11B005-738; G11B005-851
- CC 77-8 (Magnetic Phenomena)
 - Section cross-reference(s): 56
- FAN.CNT 1

I I I I I I I I I I I I I I I I I I I							
	PATENT NO.		KIND	DATE	AP	PLICATION NO.	DATE
ΡI	JP 20	02352409	A2	20021206	JР	2001-154449	20010523
	US 20	03017370	A1	20030123	US	2002-151896	20020522
PRAI	JP 20	01-154449	Α	20010523			
	US 20	01-295819P	P	20010606			

- AB The magnetic recording medium comprises, on a nonmagnetic substrate, a soft magnetic undercoat film, a magnetic orientation-controlling film, a perpendicular magnetic film, and a protective; wherein an in-plane magnetization undercoat film made of Cr (alloy) and a in-plane hard magnetization film made of a Co-Cr-Pt-X alloy (X = B, Ta, Cu, Zr, Nb, Re, Ni, Mn, ge, Si, O, N) are arranged between the substrate and the soft magnetic undercoat film. The presence of in-plane magnetization undercoat film prevents generation of noises derived from the hard magnetization film.
- ST perpendicular magnetic recording medium inplane magnetization undercoat chromium
- IT Magnetic materials
 - (in-plane hard magnetization film; prepn. of perpendicular magnetic recording medium contg. in-plane magnetization hard film and in-plane magnetization undercoat film)
- IT Magnetic memory devices
 - (prepn. of perpendicular magnetic recording medium contg. in-plane magnetization hard film and in-plane magnetization undercoat film)
- IT 476615-96-0, Boron 5, chromium 22, cobalt 61, platinum 12 476615-97-1,
 Boron 5, chromium 18, cobalt 69, platinum 8 476615-98-2,
 Chromium 21, cobalt 66, platinum 10, tantalum 3 476615-99-3, Boron 3,
 chromium 20, cobalt 66, copper 3, platinum 8 476616-00-9,
 Chromium 14, cobalt 76, platinum 8, tantalum 2 476616-01-0, Chromium 10,
 - Chromium 14, cobalt 76, platinum 8, tantalum 2 476616-01-0, Chromium 10 cobalt 78, platinum 10, tantalum 2 476616-02-1, Boron 4, chromium 25, cobalt 59, platinum 12 476616-03-2, Boron 4, chromium 24, cobalt 59, platinum 13
 - RL: TEM (Technical or engineered material use); USES (Uses) (in-plane hard magnetization film; prepn. of perpendicular magnetic recording medium contg. in-plane magnetization hard film and in-plane magnetization undercoat film)
- - RL: TEM (Technical or engineered material use); USES (Uses)
 (in-plane magnetization undercoat film; prepn. of perpendicular
 magnetic recording medium contg. in-plane magnetization hard film and
 in-plane magnetization undercoat film)
- L8 ANSWER 3 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
- AN 2002:889125 CAPLUS
- DN 137:361782
- TI Sputtering target shields for improved magnetic properties of a recording

```
medium
     Chen, Qixu; Leu, Charles; Shows, Mark Anthony; McLeod, Paul Stephen;
IN
     Ranjan, Rajiv Yadav
PA
     Seagate Technology, Inc., USA
     U.S., 10 pp.
SO
     CODEN: USXXAM
DT
     Patent
LA
     English
IC
     ICM C23C014-32
NCL
     204298110
     77-8 (Magnetic Phenomena)
CC
     Section cross-reference(s): 76
FAN.CNT 1
                                          APPLICATION NO. DATE
     PATENT NO.
                     KIND DATE
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                     ____
                                           _____
                                           US 1999-326245
                                                            19990604
     US 6482301
                      B1
                            20021119
PΤ
PRAI US 1998-88330P
                      P
                           19980604
     A collimator system is disclosed for use in an in-line pass-by sputtering
     system during the fabrication of recording media to improve the data
     storage d. and read/write performance characteristics of the media.
     collimator system includes a collimator shield and a collimator honeycomb.
     The shield includes a rectangular tube having a flange and a frame at
     inner and outer ends, resp. The various components of the shield in part
     serve to prevent possible contamination of substrates due to target atom
     accumulation on the chamber walls during the sputtering process. The
     collimator honeycomb is provided for blocking target atoms from contacting
     the substrate at low incident angles. The collimator honeycomb is
     comprised of a plurality of collimators which are identical to each other.
     In a preferred embodiment, the collimators have a hexagonal cross-section
     taken from a perspective perpendicular to the substrate. The collimators
     may also have other geometric shapes. It is also contemplated that more
     than one collimator honeycomb level be used in alternative embodiments.
     collimator sputtering target magnetic recording film
ST
IT
     Collimators
     Magnetic disks
     Magnetic recording materials
     Shields
     Sputtering targets
        (sputtering target shields for improved magnetic properties of
        recording medium)
     12635-27-7 55014-31-8
                               107593-02-2 301853-27-0
IT
     RL: PEP (Physical, engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC (Process); USES
     (Uses)
        (sputtering target shields for improved magnetic properties of
        recording medium)
              THERE ARE 13 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT
       13
RE
(1) Alex; US 5616218 A 1997 CAPLUS
(2) Anon; JP 05-311419 1993
(3) Anon; JP 05-326426 1993 CAPLUS
(4) Bunshah; US 4931158 A 1990 CAPLUS
(5) Demaray; US 5330628 A 1994 CAPLUS
(6) Hollars; US 5683561 A 1997
(7) Hurwitt; US 5223108 A 1993 CAPLUS
(8) Hurwitt; US 5415753 A 1995
(9) Krivokapic; US 5643428 A 1997
(10) Mikalsen; US 4824544 A 1989 CAPLUS
(11) Sawada; US 5804046 A 1998 CAPLUS
(12) Washburn; US 6139695 A 2000 CAPLUS
(13) Yamada; US 5744016 A 1998 CAPLUS
L8
     ANSWER 4 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
```

ΑN

2002:770073 CAPLUS

- DN 137:287959
- TI Magnetic recording medium with dual magnetic layers and high in-plane coercivity
- IN Chen, Qixu David; Huang, Lin; Leu, Charles; Ranjan, Rajiv Yadav
- PA Seagate Technology, Inc., USA
- SO U.S., 12 pp. CODEN: USXXAM
- DT Patent
- LA English
- IC ICM G11B005-66 ICS G11B005-70
- NCL 428694000TM
- CC 77-8 (Magnetic Phenomena)
- FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI US 6461750	B1	20021008	US 1999-406816	19990928
US 2003039863	A1	20030227	US 2002-252708	20020924
PRAI US 1998-102573P	P	19980930		
US 1999-406816	A3	19990928		

- AB A magnetic recording media is formed with high in-plane coercivity employing dual magnetic layers. The 1st magnetic layer is sputter deposited in a chamber employing a shield such that the min. incident angle of impinging atoms is relatively large, e.g., .gtorsim.26.degree. Embodiments of the present invention comprise depositing a NiAl seed layer, a Cr or Cr alloy underlayer and a 1st CoCrTa magnetic layer at a thickness .ltorsim.50 .ANG. for inducing the preferred (10.0) crystallog. orientation in the subsequently deposited 2nd magnetic layer, e.g., CoCrPtTa or CoCrPtTaNb having a high Cr content of .apprx.16 to .apprx.21 at.%.
- ST cobalt chromium platinum tantalum dual layer recording medium coercivity
- IT Coercive force (magnetic)

Magnetic multilayers

Magnetic recording materials

Sputtering

(cobalt-chromium alloy magnetic recording medium with dual magnetic layers and high in-plane coercivity)

- IT 7440-47-3P, Chromium, uses 12635-27-7P 77325-66-7P 137850-97-6P 238087-04-2P 467233-21-2P 467233-22-3P
 - RL: DEV (Device component use); PNU (Preparation, unclassified); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (cobalt-chromium alloy magnetic recording medium with dual magnetic layers and high in-plane coercivity)
- RE.CNT 16 THERE ARE 16 CITED REFERENCES AVAILABLE FOR THIS RECORD RE
- (1) Akimoto; IEEE Transactions on Magnetics 1998, V34(4), P1
- (2) Alex; US 5616218 A 1997 CAPLUS
- (3) Bertero; US 6150015 A 2000 CAPLUS
- (4) Bian; US 6077586 A 2000 CAPLUS
- (5) Bian; US 6143388 A 2000 CAPLUS
- (6) Chen; US 5763071 A 1998 CAPLUS
- (7) Futamoto; US 6251532 B1 2001 CAPLUS
- (8) Lee; US 5693426 A 1997 CAPLUS
- (9) Lee; US 5800931 A 1998 CAPLUS
- (10) Lee; IEEE Transactions on Magnetics 1994, V30(6), P3951 CAPLUS
- (11) Ohkubo; US 5851656 A 1998 CAPLUS
- (12) Peng; IEEE Transactions on Magnetics 1995, V31(6), P2821 CAPLUS
- (13) Ross; Journal of Applied Physics: Proceedings of the 41st Annual Conference on Magnetism and Magnetic Materials, Part 2A 1997, V81(8) CAPLUS
- (14) Song; US 6150016 A 2000 CAPLUS
- (15) Zhang; US 5772857 A 1998 CAPLUS
- (16) Zhang; US 6077603 A 2000 CAPLUS
- L8 ANSWER 5 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN

```
2002:630296 CAPLUS
ΑN
DN
     137:149161
     Magnetic recording disk for hard disk drive.
ΤI
     Lai, Tai-Huang; Luo, Yu-Yun; Tung, Jiun-Yan; Liang, Wei-Jeng; Liang,
IN
     Trace Storage Technology Corp., Taiwan
PA
SO
     Taiwan, 19 pp.
     CODEN: TWXXA5
DT
     Patent
LA
     Chinese
     ICM G11B005-62
IC
     77-8 (Magnetic Phenomena)
     Section cross-reference(s): 57
FAN.CNT 1
                                          APPLICATION NO. DATE
     PATENT NO.
                    KIND DATE
     ______
                                          -----
                                          TW 1998-87110336 19980626
     TW 392150
                      B 20000601
PRAI TW 1998-87110336
                          19980626
     The present invention relates to high-coercivity magnetic recording disk
     used in hard disk drive. The magnetic recording disk comprises a
     nonmagnetic substrate, a fine grain-structured Ni-Al alloy seed layer
     (thickness 200-1000 .ANG.) sputtered on the substrate, a Cr-V alloy
     intermediate layer (thickness 50-1000 .ANG.) sputtered on the seed layer,
     a Co-Cr-Pt-Ta-Nb alloy magnetic layer (thickness 100-400 .ANG.) sputtered
     on the intermediate layer, and a carbon protective layer sputtered on the
     magnetic layer. The nonmagnetic substrate may be made from glass,
     ceramic, glass ceramic, Al alloy, etc. The Co-Cr-Pt-Ta-Nb alloy magnetic
     layer-contg. magnetic recording disk has coercivity (Hc) higher than 4000
ST
     magnetic recording disk hard disk drive; coercivity magnetic recording
     disk hard disk drive; hard magnetic disk coercivity
IT
        (IR; magnetic recording disk for hard disk drive)
IT
     Lubricating oils
        (coating; magnetic recording disk for hard disk drive)
IT
     Coating process
        (electroless; magnetic recording disk for hard disk drive)
IT
     Magnetic disks
        (hard; magnetic recording disk for hard disk drive)
ΙT
     Coercive force (magnetic)
     Magnetic disks
     Sputtering
        (magnetic recording disk for hard disk drive)
IT
     Ceramics
     Glass ceramics
        (substrate; magnetic recording disk for hard disk drive)
IT
     Glass, uses
     RL: DEV (Device component use); USES (Uses)
        (substrate; magnetic recording disk for hard disk drive)
     Aluminum alloy, base
IT
     RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses)
        (substrate; magnetic recording disk for hard disk drive)
     11104-08-8, Nickel phosphide 12035-46-0, Nickel phosphide (NiP)
TT
     RL: TEM (Technical or engineered material use); USES (Uses)
        (coating, electroless plated; magnetic recording disk for hard disk
        drive)
IT
     37283-60-6, Chromium alloy, Cr,V
     RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses)
        (intermediate layer; magnetic recording disk for hard disk drive)
     238087-04-2, Cobalt alloy, Co,Cr,Nb,Pt,Ta 297178-07-5
IT
     444725-28-4
     RL: DEV (Device component use); PRP (Properties); USES (Uses)
        (magnetic recording disk for hard disk drive)
IT
     7440-44-0, Carbon, uses
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RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses) (protective coating; magnetic recording disk for hard disk drive) 12635-29-9, Nickel alloy, Ni, Al TT RL: DEV (Device component use); USES (Uses) (seed layer; magnetic recording disk for hard disk drive) 11145-10-1, Aluminum alloy, Al, Mg IT RL: DEV (Device component use); NUU (Other use, unclassified); USES (Uses) (substrate; magnetic recording disk for hard disk drive) ANSWER 6 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN L8AN 2002:570654 CAPLUS DN 137:118451 Perpendicular magnetic recording disk medium ΤI Hokkyo, Hirotaka; Tsuboi, Shinzo; Tagami, Katsumichi IN NEC Corporation, Japan PΑ so U.S., 188 pp. CODEN: USXXAM DT Patent LΑ English IC ICM G11B005-66 ICS G11B005-77; B32B007-02 NCL 428694000TM 77-8 (Magnetic Phenomena) Section cross-reference(s): 56 FAN.CNT 1 KIND DATE APPLICATION NO. DATE PATENT NO. ______ -----US 6426157 B1 20020730 JP 3090128 B2 20000918 US 1999-366251 19990803 JP 1998-244060 19980828 US 2002182445 A1 20021205 US 2002-141446 20020508 PRAI JP 1998-244060 A 19980828 19990803 US 1999-366251 A1 A perpendicular magnetic disk material with reduced demagnetization field AB due to magnetic poles generated on the film surface and low medium noise in the low recording d. region. The present invention provides a perpendicular magnetic recording medium having a perpendicular magnetization film formed on a substrate, wherein a high perpendicular orientation film having higher perpendicular orientation than that of the perpendicular magnetization film is formed over or/and under the perpendicular magnetization film. ST magnetic disk sputtering chromium cobalt rare earth platinum Magnetic disks IT Sputtering (perpendicular magnetic recording disk medium) 7440-37-1, Argon, uses ITRL: NUU (Other use, unclassified); USES (Uses) (perpendicular magnetic recording disk medium) IT 12009-05-1, Barium iron oxide (BaFe18027) 12014-88-9 12017-67-3 12017-71-9, Co5Y 12017-78-6 12023-91-5, Iron strontium oxide (Fe12Sr019) 12047-11-9, Barium iron oxide (BaFe12019) 12052-77-6 12214-13-0 12297-66-4 39305-53-8, Cobalt 50, platinum 50 (atomic) 39466-70-1, Iron strontium oxide (Fe18SrO27) 53239-28-4 443347-47-5 443347-48-6 RL: NUU (Other use, unclassified); PEP (Physical, engineering or chemical process); PYP (Physical process); PROC (Process); USES (Uses) (perpendicular magnetic recording disk medium) 224560-79-6, 134783-74-7, Chromium 17, cobalt 80, tantalum 3 (atomic) Chromium 19, cobalt 78, tantalum 3 (atomic) 443347-17-9, Chromium 22, cobalt 74, lanthanum 1, platinum 2, tantalum 1 (atomic) **443347-18-0**, Chromium 21, cobalt 75, lanthanum 1, platinum 2, tantalum 1 (atomic) 443347-19-1, Chromium 20, cobalt 76, lanthanum 1, platinum 2, tantalum 1 (atomic) 443347-20-4, Chromium 19, cobalt 77, lanthanum 1, platinum 2, tantalum 1 (atomic)

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443347-21-5, Chromium 18, cobalt 78, lanthanum 1, platinum 2,
     tantalum 1 (atomic) 443347-22-6, Chromium 20, cobalt 76,
     lutetium 1, platinum 2, tantalum 1 (atomic) 443347-23-7,
     Chromium 19, cobalt 77, lutetium 1, platinum 2, tantalum 1 (atomic)
     443347-24-8, Chromium 18, cobalt 78, lutetium 1, platinum 2,
                          443347-25-9, Chromium 20, cobalt 76, lanthanum 1,
     tantalum 1 (atomic)
     lutetium 1, platinum 2 (atomic)
                                       443347-26-0, Chromium 21, cobalt 75,
     lanthanum 1, lutetium 1, platinum 2 (atomic) 443347-27-1, Chromium 19,
     cobalt 77, lanthanum 1, lutetium 1, platinum 2 (atomic)
                                                               443347-28-2,
     Chromium 18, cobalt 78, lanthanum 1, lutetium 1, platinum 2 (atomic)
     443347-29-3, Chromium 20, cobalt 76, lanthanum 1, lutetium 1, tantalum 2
                443347-30-6, Chromium 22, cobalt 74, lanthanum 1, lutetium 1,
     tantalum 2 (atomic)
                           443347-31-7, Chromium 21, cobalt 75, lanthanum 1,
                                       443347-32-8, Chromium 19, cobalt 77,
     lutetium 1, tantalum 2 (atomic)
     lanthanum 1, lutetium 1, tantalum 2 (atomic)
                                                   443347-33-9, Chromium 18,
     cobalt 78, lanthanum 1, lutetium 1, tantalum 2 (atomic)
                                                               443347-34-0,
     Chromium 20, cobalt 76, praseodymium 1, strontium 1, tantalum 2 (atomic)
     443347-35-1, Chromium 22, cobalt 74, praseodymium 1, strontium 1, tantalum
                 443347-36-2, Chromium 21, cobalt 75, praseodymium 1,
     strontium 1, tantalum 2 (atomic)
                                       443347-37-3, Chromium 19, cobalt 77,
     praseodymium 1, strontium 1, tantalum 2 (atomic)
                                                        443347-38-4, Chromium
     18, cobalt 78, praseodymium 1, strontium 1, tantalum 2 (atomic)
     443347-39-5, Chromium 22, cobalt 74, lanthanum 1, lutetium 1, platinum 2
               443347-40-8, Chromium 19, cobalt 77, praseodymium 1, sulfur 1,
     tantalum 2 (atomic) 443347-41-9, Chromium 22, cobalt 74,
     lutetium 1, platinum 2, tantalum 1 (atomic)
                                                   443347-42-0, Chromium 22,
     cobalt 74, platinum 2, praseodymium 1, strontium 1 (atomic)
     Chromium 21, cobalt 75, platinum 2, praseodymium 1, strontium 1 (atomic)
     443347-44-2, Chromium 20, cobalt 76, platinum 2, praseodymium 1, strontium
     1 (atomic)
               443347-45-3, Chromium 19, cobalt 77, platinum 2, praseodymium
     1, strontium 1 (atomic)
                             443347-46-4, Chromium 18, cobalt 78, platinum 2,
     praseodymium 1, strontium 1 (atomic)
     RL: PEP (Physical, engineering or chemical process); PRP (Properties); PYP
     (Physical process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (perpendicular magnetic recording disk medium)
              THERE ARE 14 CITED REFERENCES AVAILABLE FOR THIS RECORD `
RE.CNT
(1) Anon; JP 5891 1983
(2) Anon; JP 59127235 1984 CAPLUS
(3) Anon; JP 59191130 1984
(4) Anon; JP 60239916 1985
(5) Anon; JP 618719 1986
(6) Anon; JP 1173312 1989
(7) Anon; JP 10334440 1998
(8) Anon; JP 11102510 1999
(9) Chen; US 6037052 A 2000
(10) Fukuzawa; US 6146776 A 2000 CAPLUS
(11) Honda; US 5851643 A 1998 CAPLUS
(12) Ichihara; US 6033536 A 2000 CAPLUS
(13) Kanbe; US 6080476 A 2000 CAPLUS
(14) Ouchi; Journal of Magn Soc Japan 1984, V8(1), P17 CAPLUS
     ANSWER 7 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
     2002:281325 CAPLUS
     137:40593
     Thermodynamic calculations of the effect of B and Ta on magnetically
     induced phase separation in Co-Cr-Pt alloys
     Oikawa, K.; Qin, G. W.; Okamoto, S.; Kitakami, O.; Shimada, Y.; Fukamichi,
     K.; Ishida, K.
     National Institute of Advanced Industrial Science and Technology, Sendai,
     983-8551, Japan
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Applied Physics Letters (2002), 80(15), 2704-2706

CODEN: APPLAB; ISSN: 0003-6951

RE

L8

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DN

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AU

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SO

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American Institute of Physics
PB
     Journal
DT
LA
     English
     77-1 (Magnetic Phenomena)
CC
     Section cross-reference(s): 56
     To clarify the relation between the magnetically induced phase sepn. and
AB
     the recording media characteristics, the thermodn. calcns. of Co-Cr-Pt-B
     and Co-Cr-Pt-Ta systems were carried out by the available binary
     assessment data and Miedema's semiempirical values. B is segregated to
     the boundary in a similar manner as Cr, which makes the boundary region
     paramagnetic. This result is consistent with available data that B
     weakens the intergranular magnetic coupling and increases the magnetic
     anisotropy in Co-Cr-Pt recording media. By adding Ta, the Cr content in
     the paramagnetic phase is also increased, reducing the intergranular
     magnetic coupling. However, the Ta content in the ferromagnetic phase is
     higher than in the paramagnetic phase, decreasing the magnetic anisotropy.
     Accordingly, the thermodn. calcns. successfully explain exptl. magnetic
     data for Co-Cr-Pt-B and Co-Cr-Pt-Ta recording media.
     chromium cobalt platinum boron magnetic recording medium phase sepn;
ST
     tantalum chromium cobalt platinum magnetic recording medium phase sepn
IT
     Ferromagnetic materials
     Magnetic field effects
     Magnetic recording materials
     Paramagnetic materials
     Phase separation
        (thermodn. calcns. of the effect of B and Ta on magnetically induced
        phase sepn. in Co-Cr-Pt magnetic recording media)
                                               436868-30-3 436868-31-4
IT
     436868-27-8
                   436868-28-9
                                 436868-29-0
                   436868-33-6
                                 436868-34-7
     RL: PEP (Physical, engineering or chemical process); PRP (Properties); PYP
     (Physical process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (thermodn. calcns. of the effect of B and Ta on magnetically induced
        phase sepn. in Co-Cr-Pt magnetic recording media)
RE.CNT
              THERE ARE 26 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE
(1) de Boer, F; Cohesion in Metals 1988
(2) Doerner, M; IEEE Trans Magn 2001, V37, P1502
(3) Dupin, N; J Phase Equilib 1993, V14, P451 CAPLUS
(4) Hasebe, M; J Jpn Inst Met 1982, V46, P577 CAPLUS
(5) Hillert, M; CALPHAD: Comput Coupling Phase Diagrams Thermochem 1978, V2,
    P227 CAPLUS
(6) Hirayama, Y; IEEE Trans Magn 1996, V32, P3807 CAPLUS
(7) Hono, K; Appl Phys Lett 1993, V62, P2504 CAPLUS
(8) Inaba, N; J Magn Magn Mater 1997, V168, P222 CAPLUS
(9) Ishida, K; Bull Alloy Phase Diagrams 1990, V11, P357 CAPLUS
(10) Iwasaki, S; IEEE Trans Magn 1978, V14, P849
(11) Iwase, T; Jpn J Appl Phys, Part 1 1993, V32, P3823
(12) Kitakami, O; J Magn Magn Mater 1999, V202, P305 CAPLUS
(13) Kubota, Y; J Appl Phys 1998, V84, P6202 CAPLUS
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    CAPLUS
(16) Oikawa, K; Acta Mater (in press)
(17) Oikawa, K; Appl Phys Lett 2001, V79, P644 CAPLUS
(18) Oikawa, K; J Magn Magn Mater 2001, V236, P220 CAPLUS
(19) Oikawa, K; J Magn Magn Mater 2002, V239, P409 CAPLUS
(20) Oikawa, K; J Magn Soc Jpn 2001, V25, P478 CAPLUS
```

(24) Sanchez, J; Phys Rev B 1978, V17, P2926(25) Sundman, B; CALPHAD: Comput Coupling Phase Diagrams Thermochem 1985, V9, P153 CAPLUS

(21) Paik, C; IEEE Trans Magn 1992, V28, P3084 CAPLUS (22) Qin, G; J Magn Magn Mater 2001, V234, PL1 CAPLUS

(23) Redlich, O; Ind Eng Chem 1948, V40, P345

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(26) Weller, D; Annu Rev Mater Sci 2000, V30, P611 CAPLUS
    ANSWER 8 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
     2001:564048 CAPLUS
AN
     135:146124
DN
    Anisotropic magnetic recording materials and manufacturing materials
TI
     thereof
    Hiruma, Takehiko; Suezutsumi, Michinobu; Imagawa, Makoto
IN
    Asahi Komagu K. K., Japan
PA
     Jpn. Kokai Tokkyo Koho, 4 pp.
so
     CODEN: JKXXAF
DT
    Patent
LΑ
     Japanese
     ICM G11B005-82
IC
     ICS G11B005-851
     77-8 (Magnetic Phenomena)
     Section cross-reference(s): 56, 57
FAN.CNT 1
     PATENT NO.
                    KIND DATE
                                          APPLICATION NO. DATE
     -----
                                          -----
                                                           _____
                                                           20000125
    JP 2001209927 A2
                           20010803
                                          JP 2000-15411
                           20000125
PRAI JP 2000-15411
     The title manufg. involves (1) forming a stripe texture on a glass
     substrate, (2) sputtering a Ni-P amorphous film over the texture-pattern
     on the substrate, (3) keeping the amorphous film-formed substrate in the
     atm., and (4) sputtering a Cr film, a Co-type magnetic film, and a
     protection film successively over the amorphous film on the heated
     substrate. The process provides the magnetic materials on substrates
     increased anisotropy and coercive force.
ST
     qlass substrate stripe texture anisotropy coercive force magnetic
     recording
     Sputtering
ΙT
        (anisotropic magnetic recording materials and manufg. materials
     Magnetic recording
IT
        (anisotropic; anisotropic magnetic recording materials and manufg.
        materials thereof)
     Coercive force (magnetic)
IT
     Magnetic anisotropy
        (increased; anisotropic magnetic recording materials and manufq.
        materials thereof)
IT
     Magnetic materials
       (recording materials; anisotropic magnetic recording materials and
       manufg. materials thereof)
IT
     Glass substrates
        (stripe texture on; anisotropic magnetic recording materials and
        manufg. materials thereof)
     37270-13-6P, nickel 80, phosphorus 20 (atomic)
ΙT
     RL: DEV (Device component use); PNU (Preparation, unclassified); PRP
     (Properties); PREP (Preparation); USES (Uses)
        (amorphous film, sputtering of; anisotropic magnetic recording
        materials and manufg. materials thereof)
IT
     352206-32-7P
     RL: DEV (Device component use); PNU (Preparation, unclassified); PRP
     (Properties); PREP (Preparation); USES (Uses)
        (magnetic film; anisotropic magnetic recording materials and manufg.
        materials thereof)
IT
     92840-02-3P
     RL: DEV (Device component use); PNU (Preparation, unclassified); PRP
     (Properties); PREP (Preparation); USES (Uses)
        (sublayer, sputtering; anisotropic magnetic recording materials and
        manufg. materials thereof)
```

ANSWER 9 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN

L8

```
AN
DN
     134:65375
     High coercivity, high signal-to-noise ratio dual magnetic layer media
ΤI
     Chen, Qixu; Song, Xing; Leu, Charles; Ranjan, Rajiv Yadau; Chen, Ga-Lane
IN
     Seagate Technology LLC, USA
PA
SO
     U.S., 12 pp.
     CODEN: USXXAM
DT
     Patent
LΑ
     English
     ICM G11B005-66
IC
NCL
    428336000
     77-8 (Magnetic Phenomena)
     Section cross-reference(s): 56
FAN.CNT 1
                     KIND DATE
                                          APPLICATION NO. DATE
     PATENT NO.
     _____
                                          -----
                                                           -----
    US 6168861
                     B1
                           20010102
                                          US 1998-188677
                                                           19981110
PRAI US 1997-69536P P
                           19971212
     A high areal d. magnetic recording medium with high remanent coercivity
     and high signal-to-noise ratio is formed with dual magnetic layers, the
     1st or lower magnetic layer having a higher satn. magnetization than the
     2nd or upper magnetic layer. Embodiments include 1st and 2nd magnetic
     layers contg. Co and Pt, wherein the 1st magnetic layer comprises less Pt
     than the 2nd, e.g., a 1st magnetic layer of Co-15% Cr-8% Pt-4% Ta and a
     2nd magnetic layer of Co-15% Cr-11% Pt-4% Ta.
     dual layer magnetic recording material; chromium cobalt platinum tantalum
ST
     magnetic recording
     Ceramics
TT
     Glass ceramics
     Lubricants
     Magnetic films
     Magnetic multilayers
     Magnetic recording materials
     Passivation
        (high coercivity, high signal-to-noise ratio dual magnetic layer media)
IT
     Glass, uses
     RL: TEM (Technical or engineered material use); USES (Uses)
        (high coercivity, high signal-to-noise ratio dual magnetic layer media)
                 11149-64-7
                             81705-66-0
                                           142295-96-3
TT
     219874-19-8 301853-27-0, Chromium 15, cobalt 73, platinum 8,
                314062-59-4, Chromium 14-16, cobalt 71-75, platinum 7.5-8.5,
                                314062-60-7, Chromium 14-16, cobalt 68-72,
     tantalum 3.5-4.5 (atomic)
     platinum 10.5-11.5, tantalum 3.5-4.5 (atomic)
                                                    314062-61-8, Chromium
     10-20, cobalt 74-89, tantalum 1-6 (atomic)
     RL: TEM (Technical or engineered material use); USES (Uses)
        (high coercivity, high signal-to-noise ratio dual magnetic layer media)
RE.CNT
              THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE
(1) Anon; JP 05114128 1993
(2) Chen; US 5763071 1998 CAPLUS
(3) Lal; US 5432012 1995
(4) Lal; US 5432017 1995
(5) Lal; US 6007924 1999 CAPLUS
(6) Miyazaki; US 5558945 1996
(7) Miyazaki; US 5674637 1997 CAPLUS
(8) Renjei; US 5840394 1998 CAPLUS
(9) Zhang; US 5952097 1999 CAPLUS
L8
     ANSWER 10 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
AN
     2000:806600 CAPLUS
DN
     133:343710
TI
     Substantially isotropic magnetic recording medium prepared with deposited
     seed layer before depositing the underlayer
     Song, Xing; Chen, Qixu; Leu, Charles; Ranjan, Rajiv Yadav
IN
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2001:7543 CAPLUS

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Seagate Technology, Inc., USA
PA
so
     U.S., 16 pp.
     CODEN: USXXAM
DT
     Patent
LA
     English
IC
     ICM G11B005-66
NCL
    428332000
     77-8 (Magnetic Phenomena)
CC
FAN.CNT 1
                     KIND DATE
                                         APPLICATION NO. DATE
     PATENT NO.
     _____
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                                           -----
                                          US 1998-145762
                                                           19980902
     US 6146754
                      Α
                           20001114
PΙ
PRAI US 1997-58240P
                     P
                           19970908
     A high areal d. magnetic recording medium exhibiting high Hc, high SNR,
     high S* and substantially isotropic magnetic properties is achieved by
     depositing a thin seedlayer before depositing the underlayer. Embodiments
     include heating the seedlayer under vacuum in the presence of residual O
     to induce appropriate cryst. orientation and surface morphol. for
     nucleation and growth of the underlayer and magnetic layer having
     substantially isotropic magnetic properties.
     seed layer magnetic recording; chromium oxide seed magnetic recording
ST
     Magnetic films
IT
     Magnetic recording materials
        (substantially isotropic magnetic recording medium prepd. with
        deposited seed layer before depositing underlayer)
IT
     Heat treatment
        (substantially isotropic magnetic recording medium prepd. with
        deposited seed layer treated by)
IT
     Oxidation
        (surface; substantially isotropic magnetic recording medium prepd. with
        deposited seed layer treated by)
IT
     Chromium alloy, base
     RL: PEP (Physical, engineering or chemical process); TEM (Technical or
     engineered material use); PROC (Process); USES (Uses)
        (substantially isotropic magnetic recording medium prepd. with
        deposited seed layer before depositing underlayer)
                                     11118-57-3, Chromium oxide
IT
     1309-48-4, Magnesia, processes
     RL: PEP (Physical, engineering or chemical process); TEM (Technical or
     engineered material use); PROC (Process); USES (Uses)
        (seed layer; substantially isotropic magnetic recording medium prepd.
        with deposited seed layer before depositing underlayer)
IT
     303191-86-8P
     RL: PEP (Physical, engineering or chemical process); PNU (Preparation,
     unclassified); TEM (Technical or engineered material use); PREP
     (Preparation); PROC (Process); USES (Uses)
        (substantially isotropic magnetic recording medium prepd. with
        deposited seed layer before depositing underlayer)
IT
     7440-47-3, Chromium, processes
                                    51614-60-9
                                                   81705-66-0
                                                              142295-96-3
     161078-92-8 293767-41-6, Chromium 15, cobalt 76, platinum 5,
     tantalum 4
     RL: PEP (Physical, engineering or chemical process); TEM (Technical or
     engineered material use); PROC (Process); USES (Uses)
        (substantially isotropic magnetic recording medium prepd. with
        deposited seed layer before depositing underlayer)
IT
     7782-44-7, Oxygen, processes
     RL: NUU (Other use, unclassified); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (substantially isotropic magnetic recording medium prepd. with
        deposited seed layer treated by)
              THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT
RE
(1) Chen; US 5866227 1999 CAPLUS
(2) Doener; US 5302434 1994
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(3) Lal; US 5456978 1995 CAPLUS

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(4) Lal; US 5569533 1996
(5) Laughlin; IEEE Transactions on Magnetics 1996, V32(5), P3632 CAPLUS
(6) Lee; 41st Annual Conference on Magnetism & Magnetic Materials 1996, P1
(7) Lee; IEEE Transactions on Magnetics 1994, V30(6), P3951 CAPLUS
(8) Lee; IEEE Transactions on Magnetics 1995, V31(6), P2728 CAPLUS
(9) Lee; J Appl Phys 1996, V79(8), P4902 CAPLUS
    ANSWER 11 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
    2000:768973 CAPLUS
AN
DN
    133:316730
    Magnetic recording medium with low temperature seed-layer for high
TI
    signal-to-noise ratio
    Chen, Qixu; Song, Xing; Leu, Charles; Ranjan, Rajiv
IN
    Seagate Technology LLC, USA
PΑ
SO
    U.S., 10 pp.
    CODEN: USXXAM
DT
    Patent
LA
    English
IC
    ICM G11B005-66
NCL
    428332000
    77-8 (Magnetic Phenomena)
FAN.CNT 1
                                          APPLICATION NO. DATE
    PATENT NO.
                    KIND DATE
     ______
                                          ------
                    Α
    US 6139951
                           20001031
                                          US 1998-188683 19981110
PRAI US 1997-69574P P
                           19971212
    A magnetic recording medium exhibiting high remanent coercivity and low
    noise is produced by depositing a 1st NiAl seed-layer on a nonmagnetic
    substrate, e.g., glass, ceramic or glass-ceramic material, at a relatively
     low temp., and subsequently depositing a 2nd NiAl seed-layer on the 1st
     seed-layer at a relatively higher temp. Embodiments include depositing a
     1st NiAl seed-layer at a temp. .ltorsim.120.degree.., e.g.,
     .ltorsim.100.degree.., and depositing a 2nd NiAl seed-layer thereon at a
     temp. .qtorsim.200.degree.., e.g. .qtorsim.230.degree.. Embodiments also
     include depositing a Cr-alloy underlayer, CrV, on the 2nd seed-layer.
ST
    nickel aluminum seed layer chromium alloy recording medium
    Coercive force (magnetic)
ΙT
    Glass ceramics
    Magnetic recording materials
     Remanence
        (magnetic recording medium with low temp. seed-layer for high
        signal-to-noise ratio and high remanent coercivity)
IT
    Glass, uses
    RL: DEV (Device component use); TEM (Technical or engineered material
    use); USES (Uses)
        (magnetic recording medium with low temp. seed-layer for high
        signal-to-noise ratio and high remanent coercivity)
                             161078-92-8 301853-27-0
IT
     12635-27-7 55014-31-8
     RL: DEV (Device component use); PRP (Properties); TEM (Technical or
     engineered material use); USES (Uses)
        (magnetic recording medium with low temp. seed-layer for high
        signal-to-noise ratio and high remanent coercivity)
             THERE ARE 6 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT 6
RE
(1) Chang; US 5879783 1999 CAPLUS
(2) Chen; US 5846648 1998 CAPLUS
(3) Chen; US 6010795 2000 CAPLUS
(4) Lee, L; IEEE Transactions On Magnetics 1994, V30(6), P3951 CAPLUS
(5) Ross, C; Journal of Applied Physics 1997, V81(8), P4369 CAPLUS
(6) Zhang; US 5858566 1999 CAPLUS
     ANSWER 12 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
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ΑN

DN

2000:716092 CAPLUS

133:275473

```
Fabrication of magnetic recording medium and magnetic recording disk
ΤI
     device
     Okuyama, Chiaki; Sato, Kenji; Yoshida, Yuki; Okamoto, Iwao
IN
PA
     Fujitsu Ltd., Japan
so
     U.S., 20 pp.
     CODEN: USXXAM
DT
     Patent
     English
LA
     ICM G11B005-66
IC
NCL
     428332000
     77-8 (Magnetic Phenomena)
CC
     Section cross-reference(s): 56
                                          APPLICATION NO. DATE
     PATENT NO.
                     KIND DATE
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                                           ______
                                                            19981106
     US 6129981
                      Α
                            20001010
                                          US 1998-187082
PΤ
PRAI JP 1998-39259
                     Α
                            19980220
     A magnetic recording medium and a magnetic disk device fabrication is
     presented. The magnetic recording medium comprising a nonmagnetic
     substrate having applied thereon, through a chromium-based underlayer, at
     least one magnetic recording layer consisting of cobalt as a principal
     component, 14 to 23 at % of chromium, 1 to 20 at % of platinum as well as
     tungsten and carbon. The magnetic recording medium exhibits reduced
     noise, an improved resoln. of the reproducing waveforms and an increased
     S/N ratio.
     magnetic recording medium disk device fabrication
ST
ΙT
     Magnets
        (circuits; in fabrication of magnetic recording medium and magnetic
        recording disk device)
IT
     Magnetic disks
        (fabrication of)
     Magnetic recording heads
IT
     Magnetic recording materials
        (fabrication of magnetic recording medium and magnetic recording disk
        device)
ΙT
     Controlled atmospheres
     Magnetic materials
     Sputtering
        (in fabrication of magnetic recording medium and magnetic recording
        disk device)
IT
     Electronic device fabrication
        (of magnetic recording medium and magnetic recording disk device)
IT
     7429-90-5, Aluminum, processes
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (NiP coated disk substrate; in fabrication of magnetic recording medium
        and magnetic recording disk device)
ΙT
     7440-37-1, Argon, processes
     RL: NUU (Other use, unclassified); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (atm.; in fabrication of magnetic recording medium and magnetic
        recording disk device)
IT
     12035-46-0, Nickel phosphide (NiP)
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (coated aluminum; in fabrication of magnetic recording medium and
        magnetic recording disk device)
IT
     7440-47-3, Chromium, processes
                                      129617-87-4, Chromium 13, cobalt 75,
                 297178-05-3, Carbon 1, chromium 17, cobalt 73, platinum 5,
     platinum 12
     tungsten 4 297178-06-4, Carbon 1, chromium 0-23, cobalt 67-90, platinum
     5, tungsten 4 297178-07-5, Chromium 17, cobalt 74, niobium 2,
     platinum 5, tantalum 2 297178-08-6, Chromium 0-13, cobalt 78-91, niobium
     2, platinum 5, tantalum 2 297178-09-7, Chromium 13-21, cobalt
     70-78, niobium 2, platinum 5, tantalum 2
                                                297178-10-0, Carbon 1-6,
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297178-11-1, Chromium 13-21, cobalt 72-79, niobium 1-6, platinum
     1-20, tantalum 1-6
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses).
        (in fabrication of magnetic recording medium and magnetic recording
        disk device)
IT
     112336-81-9
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (non-magnetic layer; in fabrication of magnetic recording medium and
        magnetic recording disk device)
             THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE
(1) Anon; JP 60228637 1985 CAPLUS
(2) Anon; JP 63148411 1988
(3) Anon; JP 750008 1995
(4) Anon; JP 750009 1995
(5) Chen; US 5763071 1998 CAPLUS
(6) Inoue; US 4814238 1989
(7) Ohkubo; US 5851656 1998 CAPLUS
(8) Yamaquchi; US 5552217 1996
(9) Zhang; US 5952097 1999 CAPLUS
     ANSWER 13 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
1.8
     2000:687916 CAPLUS
AN
DN
     133:246419
     Magnetic data-storage sputtering targets and methods for preparation
ΤI
     Bartholomeusz, Michael; Tsai, Michael
IN
PA
     Heraeus, Inc., USA
SO
     U.S., 35 pp.
     CODEN: USXXAM
DT
     Patent
LA
     English
IC'
     ICM H01F001-14
NCL
    148312000
     77-8 (Magnetic Phenomena)
CC
     Section cross-reference(s): 56
FAN.CNT 1
                     KIND DATE
                                          APPLICATION NO. DATE
     PATENT NO.
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                                           -----
                                                           -----
                            20000926
                                           US 1997-946360
                                                            19971007
PΙ
     US 6123783
                      Α
                      B1 '
     US 6432223
                            20020813
                                           US 2000-546015
                                                            20000410
PRAI US 1997-38031P
                      P
                            19970206
                            19971007
     US 1997-946360
                     A3
     A method for making a magnetic data storage target includes warm-rolling a
AB
     magnetic alloy sheet at a temp. of .ltorsim.1200.degree. F., optimally
     followed by annealing. The method results in increased pass-through-flux
     (PTF) and improved performance in magnetron sputtering applications.
     magnetic recording sputtering target rolling annealing; alloy magnetic
ST
     recording sputtering target rolling annealing; metal magnetic recording
     sputtering target rolling annealing
ΙT
     Magnetic recording materials
     Magnetron sputtering
     Sputtering targets
        (magnetic data-storage sputtering targets and methods for prepn.)
IT
     Annealing
     Cold rolling
        (magnetic data-storage sputtering targets and methods for prepn. using)
IT
     Alloys, processes
     Metals, processes
     RL: PEP (Physical, engineering or chemical process); TEM (Technical or
     engineered material use); PROC (Process); USES (Uses)
        (magnetic; magnetic data-storage sputtering targets and methods for
```

chromium 13-21, cobalt 52-79, platinum 1-20, tungsten 1-6

prepn.) IT Rolling (metals) (warm; magnetic data-storage sputtering targets and methods for prepn. Cobalt alloy, base IT Nickel alloy, base RL: NUU (Other use, unclassified); PEP (Physical, engineering or chemical process); TEM (Technical or engineered material use); PROC (Process); USES (magnetic data-storage sputtering targets and methods for prepn.) 7440-02-0, Nickel, processes 7440-48-4, Cobalt, processes 159455-25-1, IT Chromium 10, cobalt 86, tantalum 4 (atomic) 228254-68-0, Chromium 12, cobalt 74, nickel 10, tantalum 4 (atomic) 256455-58-0, Chromium 15, 293741-83-0, Chromium 16, cobalt 75, platinum 6, tantalum 4 (atomic) 293741-84-1, Boron 6, chromium 20, cobalt 73, platinum 11 (atomic) cobalt 64, platinum 10 (atomic) 293741-85-2, Chromium 0-40, cobalt 0-100, nickel 0-100, tantalum 0-8 (atomic) 293741-86-3, Chromium 0-40, cobalt 0-100, nickel 0-100, platinum 0-30, tantalum 0-8 (atomic) 293741-87-4, Boron 0-30, chromium 0-40, cobalt 0-100, nickel 0-100, 293741-88-5, Chromium 0-40, cobalt 0-100, nickel tantalum 0-8 (atomic) 0-100, silicon 0-30, tantalum 0-8 (atomic) 293741-89-6, Chromium 0-40, cobalt 0-100, nickel 0-100, tantalum 0-8, zirconium 0-30 (atomic) 293741-90-9, Chromium 0-40, cobalt 0-100, iron 0-30, nickel 0-100, tantalum 0-8 (atomic) 293741-91-0, Chromium 0-40, cobalt 0-100, nickel 0-100, tantalum 0-8, tungsten 0-30 (atomic) 293741-92-1, Chromium 0-40, cobalt 0-100, molybdenum 0-30, nickel 0-100, tantalum 0-8 (atomic) 293741-93-2, Chromium 0-40, cobalt 0-100, nickel 0-100, tantalum 0-8, vanadium 0-30 (atomic) 293741-94-3, Chromium 0-40, cobalt 0-100, nickel 0-100, niobium 0-30, tantalum 0-8 (atomic) 293741-95-4, Chromium 0-40, cobalt 0-100, hafnium 0-30, nickel 0-100, tantalum 0-8 (atomic) 293741-96-5, Chromium 0-40, cobalt 0-100, nickel 0-100, tantalum 0-8, titanium 0-30 (atomic) 293741-97-6, Chromium 0-40, cobalt 0-100, nickel 0-100, samarium 0-30, tantalum 0-8 (atomic) RL: NUU (Other use, unclassified); PEP (Physical, engineering or chemical process); TEM (Technical or engineered material use); PROC (Process); USES (Uses) (magnetic data-storage sputtering targets and methods for prepn.) RE.CNT THERE ARE 5 CITED REFERENCES AVAILABLE FOR THIS RECORD (1) Anon; JP 1100219 1989 (2) Chan, L; Journal of Magnetism and Magnetic Materials 1989, V79, P95 CAPLUS (3) Inoue; US 5500057 1996 CAPLUS (4) Taniguchi; US 5334267 1994 CAPLUS (5) Weigert, M; Materials Science and Engineering 1991, VA139, P359 CAPLUS ANSWER 14 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN L8 AN 2000:491921 CAPLUS DN 133:243138 Self-affine nature of thin film surface TI ΑU Li, J. M.; Lu, L.; Su, Y.; Lai, M. O. Department of Mechanical and Production Engineering, National University CS of Singapore, Singapore Applied Surface Science (2000), 161(1-2), 187-193 SO CODEN: ASUSEE; ISSN: 0169-4332 PB Elsevier Science B.V. DT Journal LА English CC 66-3 (Surface Chemistry and Colloids) Section cross-reference(s): 77 Variation-correlation function (VCF), a fractal model for quant. anal. on AB 3-dimensional surface, was applied to the description of Co-based thin film surfaces imaged by at. force microscope (AFM). The results of 2 group expts. on the thin films have implied that the change in fractal dimension Dcor is in accordance with that in surface energy Esv of the

thin films but height roughness Ra and root-mean-square are not. A theor. equation was developed to demonstrate the relation between fractal dimension Dcor and surface energy Esv. This equation shows that Dcor can be interpreted as a parameter of surface energy in thin film growth, and thus the thin film surfaces have fractal nature. This equation also successfully explains the phenomenon of fractal dimension decrease for the thin films during annealing. VCF method provides a reasonable parameter for quant. description of irregularity of thin film surfaces.

ST self affinity film variation correlation function; magnetic film surface energy fractal

IT Magnetic films

(application of variation-correlation function to description of Co-based magnetic film surfaces imaged by AFM to study self-affine nature of thin film surface)

IT Films

Fractals

Surface energy

(relation between surface energy and fractal parameter of thin film using variation-correlation function)

IT 293767-41-6

RL: PRP (Properties)

(application of variation-correlation function to description of Co-based magnetic film surfaces imaged by AFM to study self-affine nature of thin film surface)

IT 7631-86-9, Silica, properties 92839-06-0

RL: PRP (Properties)

(application of variation-correlation function to description of CoCrPt-SiO2 magnetic film surfaces imaged by AFM to study self-affine nature of thin film surface)

RE.CNT 14 THERE ARE 14 CITED REFERENCES AVAILABLE FOR THIS RECORD RE

- (1) Digital Instrument; Reference Manual for Nanoscope 3 1996
- (2) Dubuc, B; Phys Rev A 1989, V39, P1500
- (3) Family, F; Dynamics of Fractal Surfaces 1991
- (4) Family, F; J Phys A: Math Gen 1985, V18, P75
- (5) Jeffries, J; Phys Rev Lett 1996, V76, P4931 CAPLUS
- (6) Krim, J; Int J Mod Phys B 1995, V9, P599 CAPLUS
- (7) Li, J; J Appl Phys 1999, V86, P2526 CAPLUS
- (8) Messier, R; J Appl Phys 1982, V54, P6220
- (9) Movchan, B; Phys Met Metallogr 1969, V28, P83
- (10) Palasantzas, G; Phys Rev Lett 1994, V73, P3564 CAPLUS
- (11) Porter, D; Phase Transformation in Metals and Alloys 1995
- (12) Yang, H; Diffraction from Rough Surface and Dynamic Growth Fronts 1993
- (13) Yang, H; Phys Rev Lett 1994, V73, P2348 CAPLUS
- (14) Yehoda, J; Appl Surf Sci 1985, V22/23, P590
- L8 ANSWER 15 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
- AN 2000:274654 CAPLUS
- DN 132:302339
- TI Magnetic recording media and magnetic disk apparatus
- IN Sato, Kenji; Yoshida, Yuki; Okuyama, Tomoaki
- PA Fujitsu Ltd., Japan
- SO Jpn. Kokai Tokkyo Koho, 16 pp. CODEN: JKXXAF
- DT Patent
- LA Japanese
- IC ICM G11B005-66 ICS H01F010-26; H01F010-30
- CC 77-8 (Magnetic Phenomena)

FAN.CNT 1

PATENT NO. KIND DATE APPLICATION NO. DATE

PI JP 2000123345 A2 20000428 JP 1998-298665 19981020

PRAI JP 1998-298665 19981020

```
Magnetic recording layers from ferromagnetic substances are formed on
AB
     nonmagnetic substrates, and antiferromagnetic base layers are formed in
     contact with the recording layers.
    magnetic recording media disk app; ferromagnetic elec magnetic recording
ST
    media
    Ferromagnetic films
IT
     Magnetic disks
     Magnetic recording materials
        (magnetic recording media and magnetic disk app.)
                 264870-62-4 264870-63-5
     69020-63-9
IT
     RL: DEV (Device component use); USES (Uses)
        (magnetic recording media and magnetic disk app. contg.
        antiferromagnetic materials)
     264870-64-6
IT
     RL: DEV (Device component use); USES (Uses)
        (magnetic recording media and magnetic disk app. contg. ferromagnetic
        materials)
    ANSWER 16 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
     1999:260977 CAPLUS
AN
DN
     130:319916
     Magnetic recording medium, magnetic cobalt alloy film, and sputtering
ΤI
     Sakawaki, Akira; Kanazawa, Hiroshi; Ohnami, Kazunori; Sakai, Hiroshi
ΙN
PA
     Showa Denko K. K., Japan
     Jpn. Kokai Tokkyo Koho, 4 pp.
so
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
IC
     ICM H01F010-16
     ICS G11B005-66
     77-8 (Magnetic Phenomena)
     Section cross-reference(s): 56, 75
FAN.CNT 1
                                          APPLICATION NO. DATE
     PATENT NO.
                  KIND DATE
                                          -----
     ______
    JP 11111524 A2 19990423
                                          JP 1997-267470 19970930
PRAI JP 1997-267470
                          19970930
     The alloy film contains Cr 10-26, Pt 1-16, Ta 1-7, Zr 0.5-4 at.%, and
     balance Co. The recording medium having the alloy film is also claimed.
     The recording medium may have a nonmagnetic underlayer contg. 5-60 at.% W
     and balance Cr. The sputtering target comprises a sintered material
     contg. Cr 10-26, Pt 1-16, Ta 1-7, Zr 0.5-4 at.%, and balance Co. The film
     shows high coercive force and low noise.
     cobalt alloy film magnetic recording medium; sputtering target cobalt
ST
     alloy magnetic film; chromium tungsten underlayer magnetic recording
     medium
     Magnetic disks
IT
     Magnetic recording materials
     Sputtering targets
        (cobalt alloy film with high coercive force for magnetic recording
        medium and sputtering target)
     223609-69-6, Chromium 18, cobalt 69, platinum 9, tantalum 2, zirconium 2
               223609-70-9, Chromium 18, cobalt 67, platinum 9, tantalum 5,
                           223609-71-0, Chromium 18, cobalt 75, platinum 9,
     zirconium 1 (atomic)
     tantalum 1, zirconium 3 (atomic)
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); TEM (Technical or engineered material use); PROC (Process); USES
        (cobalt alloy film with high coercive force for magnetic recording
        medium and sputtering target)
```

IT 223609-72-1 223609-73-2

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(cobalt alloy film with high coercive force for magnetic recording medium and sputtering target) 124798-68-1, Chromium 85, molybdenum 15 (atomic) 174321-15-4, Chromium 85, titanium 15 (atomic) 223609-74-3, Chromium 85, tungsten 15 (atomic) 223609-75-4, Chromium 40-95, tungsten 5-60 (atomic) RL: DEV (Device component use); USES (Uses) (underlayer; cobalt alloy film with high coercive force for magnetic recording medium and sputtering target) ANSWER 17 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN 1998:398633 CAPLUS 129:130319 Magnetic recording media with high magnetic coercive force and low noise

ΤI and their manufacture by sputtering Moroishi, Keiji; Tomiyasu, Hiroshi; Watanabe, Tsuyoshi IN

Hoya Corp., Japan PA Jpn. Kokai Tokkyo Koho, 10 pp. SO

CODEN: JKXXAF

DT Patent

IT

L8

AN

DN

LΑ Japanese

ICM G11B005-66 IC

ICS C23C014-14; G11B005-85; H01F010-16; H01F041-18

77-8 (Magnetic Phenomena)

Section cross-reference(s): 56

FAN.CNT 1

PΤ

PATENT NO. KIND DATE APPLICATION NO. DATE ______ _____ _____ JP 1996-313417 JP 10162336 A2 19980619 19961125 PRAI JP 1996-313417 19961125

Title media involve glass substrates and successively laminated layers of (A) Al-based 1st base layers, (B) Cr-based 2nd base layers, (C) the 3rd base layers comprising Mo, Zr, B, Si, Zn, Ti, W, V, Ta, and/or Al and Cr, (D) magnetic layers of Co alloys contg. Cr, Pt, and Ta, and (E) protective layers (preferably C). The grain size in B, C, and D is 50-300 .ANG.. Preferably, nonmagnetic spacer layers may be inserted in plural magnetic layers. The sputtering is carried out at inert-gas pressure 4-15 mTorr for A and for B, and at 0.5-6 mTorr for magnetic layers represented by Co100-x-y-zCrxPtyTaz (x = 5-20; y = 3-16; z = 1-7 at.%).

magnetic recording medium base layer structure; aluminum chromium base ST layer magnetic recording; cobalt chromium platinum tantalum magnetic recording; magnetron sputtering pressure magnetic recording medium; grain size base film magnetic recording

IT Aluminosilicate glasses

> RL: DEV (Device component use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(lithium sodium zirconium aluminosilicate, substrates; manuf. of magnetic recording media including laminated base layers and Co alloy magnetic layers)

Magnetic recording materials IT

Magnetron sputtering

(manuf. of magnetic recording media including laminated base layers and Co alloy magnetic layers)

7440-47-3P, Chromium, uses 39314-47-1P IT 7429-90-5P, Aluminum, uses 59124-10-6P 141201-23-2P 51614-60-9P

RL: DEV (Device component use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)

(base layers; manuf. of magnetic recording media including laminated base layers and Co alloy magnetic layers)

210180-78-2P, Chromium 13, cobalt 80, platinum 6, tantalum 1 (atomic) IT 210180-80-6P, Chromium 13, cobalt 74, platinum 6, tantalum 4 (atomic) 210180-82-8P, Chromium 14, cobalt 75, platinum 9, tantalum 2 (atomic) 210180-84-0P, Chromium 13, cobalt 68, platinum 11, tantalum 3 (atomic) 210180-86-2P, Chromium 8, cobalt 83, platinum 6, tantalum 3 (atomic) 210180-88-4P, Chromium 15, cobalt 76, platinum 6, tantalum 3 (atomic)

```
210180-90-8P, Chromium 13, cobalt 73, platinum 6, tantalum 3 (atomic)
     210180-92-0P, Chromium 5-20, cobalt bal., platinum 3-16, tantalum
     RL: DEV (Device component use); IMF (Industrial manufacture); PREP
     (Preparation); USES (Uses)
        (magnetic layers; manuf. of magnetic recording media including
        laminated base layers and Co alloy magnetic layers)
IT
     7440-44-0, Carbon, uses
     RL: DEV (Device component use); USES (Uses)
        (protective layers; manuf. of magnetic recording media including
        laminated base layers and Co alloy magnetic layers)
     1313-59-3, Sodium oxide, processes 1314-23-4, Zirconia, processes
IT
     1344-28-1, Alumina, processes 7631-86-9, Silica, processes
     Lithia, processes
     RL: DEV (Device component use); PEP (Physical, engineering or chemical
     process); PROC (Process); USES (Uses)
        (substrates; manuf. of magnetic recording media including laminated
        base layers and Co alloy magnetic layers)
     ANSWER 18 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
     1997:732531 CAPLUS
AN
     128:9677
DN
     Magnetic recording medium and disk apparatus
ΤI
     Okuyama, Tomoaki; Sato, Kenji; Okamoto, Iwao; Shinohara, Masayoshi
IN
PA
     Fujitsu Ltd., Japan
     Jpn. Kokai Tokkyo Koho, 22 pp.
SO
     CODEN: JKXXAF
     Patent
DT
LA
     Japanese
IC
     ICM G11B005-66
     ICS G11B005-02; G11B005-39; G11B005-85; H01F010-16
     77-8 (Magnetic Phenomena)
     Section cross-reference(s): 56
FAN.CNT 1
                    KIND DATE
                                         APPLICATION NO. DATE
     PATENT NO.
                    ----
                                         -----
                      A2 19971111
                                          JP 1996-107678
                                                           19960426
PΙ
     JP 09293227
                           20000606
                                          US 1997-797685 19970131
     US 6071607
                     Α
PRAI JP 1996-107678
                           19960426
     A magnetic recording medium comprises a nonmagnetic support successively
     laminated with a nonmagnetic metal backing layer contg. Cr and optionally
     Mo as main components, and a magnetic recording film contg. Co, Cr, Ta,
     and/or Pt as main components. A magnetic recording app. comprise the
     claimed magnetic recording medium and a magnetoresistive head. The
     recording medium enables high-d. recording and shows high coercive force,
     low noises, and high S/N ratio.
ST
     magnetic recording medium alloy; cobalt alloy magnetic recording medium;
     chromium alloy magnetic recording medium; tantalum alloy magnetic
     recording medium; platinum alloy magnetic recording medium
IT
     Magnetic memory devices
        (magnetic recording app. using magnetic recording medium made of
        transition metal alloy)
     184221-26-9, Chromium 17, cobalt 74, platinum 5, tantalum 4 (atomic)
IT
     198894-89-2, Chromium 15, cobalt 77, platinum 4, tantalum 4 (atomic)
     198894-91-6, Chromium 17, cobalt 74, niobium 2, platinum 5, tantalum 2
              198894-93-8, Chromium 17, cobalt 74, niobium 4, platinum 5
     (atomic)
     (atomic) 198894-95-0 198894-97-2
                                        198894-99-4
     198895-01-1
     RL: DEV (Device component use); USES (Uses)
        (magnetic recording layer; magnetic recording app. using magnetic
        recording medium made of transition metal alloy)
     7440-47-3, Chromium, uses 37373-03-8, Chromium 80, molybdenum 20
ΙŢ
     (atomic) 85265-02-7, Chromium 80-90, molybdenum 10-20 (atomic)
     146077-79-4, Chromium 90, molybdenum 10 (atomic)
                                                     198895-03-3, Chromium
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* •

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70-90, molybdenum 10-30 (atomic)
    RL: DEV (Device component use); USES (Uses)
        (nonmagnetic backing layer; magnetic recording app. using magnetic
       recording medium made of transition metal alloy)
    ANSWER 19 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
    1996:212161 CAPLUS
AN
DN
    124:305319
    Metal film magnetic recording material
TI
    Yo, Kyoha; Akita, Ken; Maeda, Makoto; Okumura, Yoshinobu
IN
    Kubota Kk, Japan
PA
     Jpn. Kokai Tokkyo Koho, 4 pp.
SO
    CODEN: JKXXAF
DT
    Patent
    Japanese
LA
IC
     ICM H01F010-16
     ICS G11B005-66
     77-8 (Magnetic Phenomena)
    Section cross-reference(s): 56
FAN.CNT 1
    PATENT NO.
                    KIND DATE
                                         APPLICATION NO. DATE
                                         -----
     -----
    JP 08031638 A2 19960202
                                         JP 1994-164122 19940715
PRAI JP 1994-164122
                          19940715
    The material consists of a nonmagnetic support successively coated with an
    underlayer, a Co alloy magnetic layer contg. Cr 6-20, Ta .ltoreq.9, and Cu
     0.5-7 at.%, and a protective layer. The material may contain .ltoreq.20
     at. % Pt and .ltoreq.8 at. % B. The material shows high coercive force.
    recording magnetic cobalt alloy
st
IT
    Recording materials
        (magnetic, magnetic recording material having copper-contg. cobalt
        alloy magnetic layer with high coercive force)
                  175785-18-9
                               175785-19-0
                                              175863-41-9 175863-42-0
IT
    175785-17-8
     175863-43-1
     RL: DEV (Device component use); USES (Uses)
        (magnetic recording material having copper-contg. cobalt alloy magnetic
        layer with high coercive force)
     175785-16-7
IT
     RL: DEV (Device component use); TEM (Technical or engineered material
     use); USES (Uses)
        (magnetic recording material having copper-contg. cobalt alloy magnetic
        layer with high coercive force)
IT
     7440-50-8, Copper, uses
     RL: DEV (Device component use); MOA (Modifier or additive use); USES
     (Uses)
        (microalloying element; magnetic recording material having
        copper-contq. cobalt alloy magnetic layer with high coercive force)
IT
     7440-44-0, Carbon, uses
     RL: DEV (Device component use); USES (Uses)
        (protective layer; magnetic recording material having copper-contg.
        cobalt alloy magnetic layer with high coercive force)
IT
     7429-90-5, Aluminum, uses 11149-64-7
     RL: DEV (Device component use); USES (Uses)
        (substrate; magnetic recording material having copper-contg. cobalt
        alloy magnetic layer with high coercive force)
IT
     7440-47-3, Chromium, uses
     RL: DEV (Device component use); USES (Uses)
        (underlayer; magnetic recording material having copper-contg. cobalt
        alloy magnetic layer with high coercive force)
    ANSWER 20 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
L8
     1995:774742 CAPLUS
AN
DN
     123:184164
     Cobalt-based alloy target for magnetron sputtering apparatus
ΤI
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Schlott, Martin; Weigert, Martin; Gehman, Bruce; Teng, Kwei
IN
PΑ
     Leybold Materials GmbH, Germany
SO
     Eur. Pat. Appl., 10 pp.
     CODEN: EPXXDW
DT
     Patent
LΑ
     German
     ICM C23C014-34
IC
     ICS G11B005-64; C22C019-00; C22F001-00
     75-1 (Crystallography and Liquid Crystals)
CC
FAN.CNT 1
     PATENT NO.
                     KIND DATE
                                          APPLICATION NO. DATE
     -----
                                          -----
    EP 659901 A1 19950628
EP 659901 B1 19980415
                                          EP 1994-112342 19940808
        R: DE, FR, GB, IE
     DE 4410114 A1 19950622
                                          DE 1994-4410114 19940324
     GB 2285269
                     A1 19950705
                                          GB 1994-22161
                                                           19941103
     GB 2285269
                     B2 19970611
     US 5728279
                     Α
                          19980317
                                          US 1994-356109
                                                           19941215
     JP 08027570 A2 19960130
                                          JP 1994-334937
                                                           19941220
PRAI DE 1993-4343440 19931220
DE 1994-4410114 19940324
    DE 1994-4410114
                          19940324
     The target comprises an alloy of the general formula Co1-x-yMxRy, where M
     = Cr, Pt, Ni, Pd, and/or other similar transition metal; 0 .ltoreq. x
     .ltoreq. 0.3; R = Ta, Mo, W, B, Hf, Nb, V, and/or other metals which tend
     to form intermetallic phases; and 0.015 .ltoreq. y .ltoreq. 0.20, has a
     structure of predominantly hexagonal Co mixed crystals and optionally
     R-contg. intermetallic phases, and has .gtoreq.1 of the following
     characteristics: (a) the grain boundaries, sub-grain boundaries, twin
    boundaries, or slip bands of the Co mixed crystals forming the matrix are
     decorated with the elements forming the intermetallic phases; (b) x-ray
     diffraction patterns of the target show reflections of an intermetallic
     phase which is essentially absent in the cast state and is formed during
     annealing in a temp. range below the solidus temp. by a solid-state
     reaction.
ST
     cobalt alloy target magnetron sputtering app
IT
     Sputtering
        (app., cobalt-based alloy target for magnetron sputtering app.)
IT
     Electric discharge devices
        (sputtering, cobalt-based alloy target for magnetron sputtering app.)
IT
     Cobalt alloy, base
     RL: DEV (Device component use); USES (Uses)
        (cobalt-based alloy target for magnetron sputtering app.)
     146279-48-3, Chromium 10, cobalt 84, tantalum 6 (atomic)
TT
                                                             149321-34-6,
     Chromium 10.5, cobalt 85.5, tantalum 4 (atomic)
                                                    167309-08-2
     167309-09-3 167469-90-1 167469-91-2
     RL: DEV (Device component use); USES (Uses)
        (magnetron sputtering target from)
L8
    ANSWER 21 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN
AN
     1995:682756 CAPLUS
     123:63362
DN
    Alloys and dispersion composites for coating resistant to hot corrosion
ΤI
     and oxidation in gas-turbine service
IN
    Bettridge, David Frederick; Taylor, Thomas Alan; Tucker, Robert Clark, Jr.
    Rolls-Royce PLC, UK; Praxair Inc.
PA
    Eur: Pat. Appl., 19 pp.
SO
     CODEN: EPXXDW
DT
    Patent
LΑ
    English
IC
     ICM C23C004-06
     ICS C23C030-00; C23C004-18
CC
     56-3 (Nonferrous Metals and Alloys)
     Section cross-reference(s): 57
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APPLICATION NO. DATE
     PATENT NO.
                  KIND DATE
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                                           -----
     _____
    EP 652299 A1 19950510
                                          EP 1994-308035
                                                             19941101
PΙ
     EP 652299
                     B1 19961227
         R: AT, CH, DE, FR, GB, IT, LI, SE
    US 5455119 A 19951003 US 1993-148460 19931108
    AT 146825 E 19970115
CA 2135233 AA 19950509
CA 2135233 C 19980714
BR 9404361 A 19950704
CN 1105396 A 19950719
CN 1055512 B 20000816
JP 07252674 A2 19951003
JP 2920076 B2 19990719
US 1993-148460
                                           AT 1994-308035 19941101
                                           CA 1994-2135233 19941107
                                           BR 1994-4361
                                                           19941107 -
                                           CN 1994-118165 19941107
                                           JP 1994-295973 19941107
JP 2920076 B2 19990719
PRAI US 1993-148460 A 19931108
     The MCrAlY-type alloys suitable for spray coating (as well as for
     composites with oxide dispersion) contain M (as Fe, Co, and/or Ni)
     nominally at 19-83, Cr 10-50, Al 4-14, Y (and optionally Hf) 0.1-3, and
     optionally addnl. Ta, Re, and/or Pt at 3-14 wt.%. The alloys are
     preferably used as composite with an oxide dispersion (esp. Al2O3) at 5-20
     vol.%, and are suitable for coating of superalloy parts operating in
     high-temp. oxidizing environments. The alloy or composite layer is
     optionally coated with a top layer of ZrO2 or Al and/or Cr, and is
     suitable for thermal barrier service. The typical alloy for powder-spray
     coating 6 mils thick on Mar-M-002 superalloy for gas turbine service
     contains Co 32, Ni 32, Cr 21, Al 8, Y 0.5, and Pt 6 wt.%.
     cobalt chromium aluminum yttrium alloy coating; nickel chromium aluminum
ST
     alloy coating; turbine coating chromium aluminum alloy; oxide composite
     chromium alloy coating; thermal barrier chromium alloy composite
IT
    Turbines
        (coatings for; alloy composites with oxide dispersion for coating
        resistant to hot corrosion and oxidn. in gas-turbine service)
IT
     Aluminizing
     Chromizing
        (coatings with; alloy composites with oxide dispersion for coating
        resistant to hot corrosion and oxidn. in gas-turbine service)
     Coating materials
IT
        (composites; alloy composites with oxide dispersion for coating
        resistant to hot corrosion and oxidn. in gas-turbine service)
IT
     Alloys, uses
     RL: TEM (Technical or engineered material use); USES (Uses)
        (thermal barriers on; alloy composites with oxide dispersion for
        coating as thermal barrier on superalloy parts in gas-turbine service)
     7429-90-5, Aluminum, uses 7439-89-6, Iron, uses 7440-02-0, Nickel,
TT
          7440-06-4, Platinum, uses 7440-15-5, Rhenium, uses 7440-25-7,
     Tantalum, uses 7440-47-3, Chromium, uses 7440-48-4, Cobalt, uses
     7440-58-6, Hafnium, uses 7440-65-5, Yttrium, uses
     RL: MOA (Modifier or additive use); USES (Uses)
        (alloys contg.; alloys and dispersion composites for coating resistant
        to hot corrosion and oxidn. in gas-turbine service)
     61048-41-7 61048-42-8
TT
     RL: MOA (Modifier or additive use); USES (Uses)
        (coatings; alloy composites with oxide dispersion for coatings
        resistant to hot corrosion and oxidn. in gas-turbine service)
     165047-03-0 165047-04-1 165047-05-2
                                              165047-06-3 165047-07-4
IT
     165047-08-5 165047-09-6 165047-10-9 165047-11-0 165047-12-1
     165047-13-2 165047-14-3 165047-15-4 165047-16-5
     165102-69-2 165102-70-5 165102-71-6 165102-72-7 165102-73-8
     165102-74-9 165102-75-0 165102-76-1 165102-77-2
     RL: TEM (Technical or engineered material use); USES (Uses)
        (coatings; alloy composites with oxide dispersion for coatings
        resistant to hot corrosion and oxidn. in gas-turbine service)
IT
     1314-20-1, Thoria, uses 1314-23-4, Zirconia, uses 1314-36-9, Yttria,
```

FAN.CNT 1

(dispersed; alloy composites with oxide dispersion for coatings resistant to hot corrosion and oxidn. in gas-turbine service) ANSWER 22 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN L8 1994:643931 CAPLUS AN DN 121:243931 Thin-film magnetic recording medium with a composition gradient ΤI Lal, Brij B.; Eltoukhy, Atef H. IN HMT Technology Corp., USA PA so U.S., 12 pp. CODEN: USXXAM DTPatent English LA IC ICM B32B005-14 ICS H01F001-00 NCL 428610000 CC 77-8 (Magnetic Phenomena) FAN.CNT 6 PATENT NO. KIND DATE APPLICATION NO. DATE ----------US 5324593 A 19940628 US 1992-837855 19920218 A 19941018 US 1992-995879 19921223 US 5356522 US 5366607 A 19941122 US 1992-995688 19921223 PRAI US 1991-740436 19910805 US 1992-837855 19920218 US 1992-964745 19921022 A magnetic recording disk has a magnetic film formed of lower and upper AB sublayers. The 2 sublayers are characterized by lower coercivity, smaller grains, and more isolated grains in the lower sublayer, and higher coercivity and larger grains in the upper sublayer. In 1 embodiment, the sublayers are characterized by an increasing magnetic remanence on progressing from the outer to the inner diam. of the disk, due to a compn. gradient. stmagnetic recording thin film medium; compn gradient magnetic recording medium; remanence gradient magnetic recording medium IT Recording materials (magnetic, thin-film, having compn. gradient) IT 158318-79-7 **158318-80-0** RL: USES (Uses) (magnetic recording medium contg. films of) 18 ANSWER 23 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN AN 1993:522953 CAPLUS DN 119:122953 ΤI Cobalt-chromium-platinum alloys for sputtering targets in application of magnetic recording films IN Kinoshita, Makoto; Ishii, Toshinori; Tamura, Jun; Kishida, Kunio Mitsubishi Materials Corp, Japan PA so Jpn. Kokai Tokkyo Koho, 10 pp. CODEN: JKXXAF DT Patent Japanese LA IC ICM C23C014-14 ICS C23C014-34 CC 56-4 (Nonferrous Metals and Alloys) Section cross-reference(s): 77 FAN.CNT 1 PATENT NO. KIND DATE APPLICATION NO. DATE ----------PRAI JP 1991-76575

AB The torus JP 1991-76575 19910409

The targets useful for coating with high coercive force in magnetic

1344-28-1, Alumina, uses 12055-23-1, Hafnia

RL: MOA (Modifier or additive use); USES (Uses)

. . .

uses

recording app. are manufd. from the Co alloys contg. Cr 5-20, Pt 10-55%, and optionally Ni, Ta, Pd, and/or Nb 0.1-20% each, Zr, Ti, Hf, Al, Si, Mo, W, V, and/or Cu 0.01-7% each, and/or Mg, Ca, La, Ce, and/or Nd 0.005-3% each. sputtering target cobalt alloy; cobalt chromium platinum alloy sputtering; ST magnetic recording cobalt alloy Recording materials IT (cobalt-chromium-platinum alloys, sputtered coating with) IT Coercive force, magnetic (of cobalt-chromium-platinum alloys, in magnetic recording) ΙT Sputtering (targets, cobalt-chromium-platinum alloys, in magnetic recording) 148942-10-3 148942-11-4 148942-12-5 148942-13-6 IT 148942-09-0 148942-14-7 148942-15-8 148942-16-9 148942-17-0 148942-18-1 148942-19-2 148942-20-5 148942-21-6 148942-22-7 148942-23-8 148942-26-1 148942-27-2 148942-28-3 148942-24-9 148942-25-0 148942-29-4 148942-30-7 **148994-33-6** 148994-34-7 148994-35-8 **148994-36-9 148994-37-0** 148994-38-1 149531-05-5 RL: USES (Uses) (sputtering target, for magnetic recording app.) ANSWER 24 OF 24 CAPLUS COPYRIGHT 2003 ACS on STN L8 1992:97998 CAPLUS AN 116:97998 DN High-coercivity thin-film recording medium ΤI Lal, Brij B.; Eltoukhy, Atef H. IN HMT Technology Corp., USA PΑ U.S., 19 pp. Cont.-in-part of U.S. Ser. No. 567,598. so CODEN: USXXAM DT Patent LΑ English ICM B32B015-01 IC 428611000 NCL 77-8 (Magnetic Phenomena) CC Section cross-reference(s): 56 FAN.CNT 1 PATENT NO. KIND DATE APPLICATION NO. DATE ----------____ 19910917 US 1990-626193 19901212 PΙ US 5049451 Α US 1991-669888 19910314 US 5057200 19911015 Α PRAI US 1990-567598 19900815 The medium comprises a sputtered Cr underlayer, preferably 300-1000 .ANG. thick, and a sputtered magnetic layer, preferably 200-800 .ANG. thick, from an alloy of the compn. Co 70-80, Cr 10-20, Pt 3-20, and Ta 2-10 at.%. The medium has high coercivity, signal resoln. and amplitude, and loop squareness, and low bit shift. high coercivity magnetic recording medium; chromium underlayer magnetic strecording medium; cobalt alloy magnetic recording medium; platinum tantalum chromium cobalt magnetic recording ITRecording materials (magnetic, cobalt-chromium-platinum-tantalum alloy sputtered film, on chromium underlayer) IT 139104-76-0 RL: USES (Uses) (magnetic recording medium contg. sputtered film of, with chromium underlayer) ΙT 7440-47-3, Chromium, uses RL: USES (Uses)

(underlayer from, in magnetic recording medium)

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